



國家同步輻射研究中心
National Synchrotron Radiation Research Center

Photoemission (I) Spectroscopy

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National Synchrotron Radiation Research Center

NSRRC



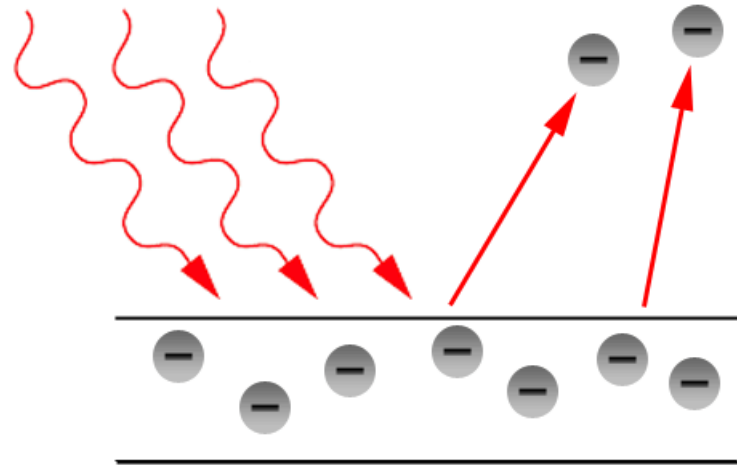
Outline

1. What is photoemission spectroscopy?
2. Fundamental aspects of photoemission.
3. Examples.
4. Increase bulk sensitivity: HAXPES.
5. Challenging future directions.

General reference books:

1. "Photoelectron Spectroscopy" 3rd Ed. by S. Hufner, Springer-Verlag 2003
2. "Angle-Resolved Photoemission: Theory and Current Applications", S. D. Kevan, ed., Amsterdam; Elsevier 1992

What is photoemission?



Photon in \rightarrow electron out (emission)

What are the samples and probed states?

Atoms

atomic orbitals (states)

Molecules

molecular orbitals

core level states (atomic like)

Nanoparticles

valence bands/states

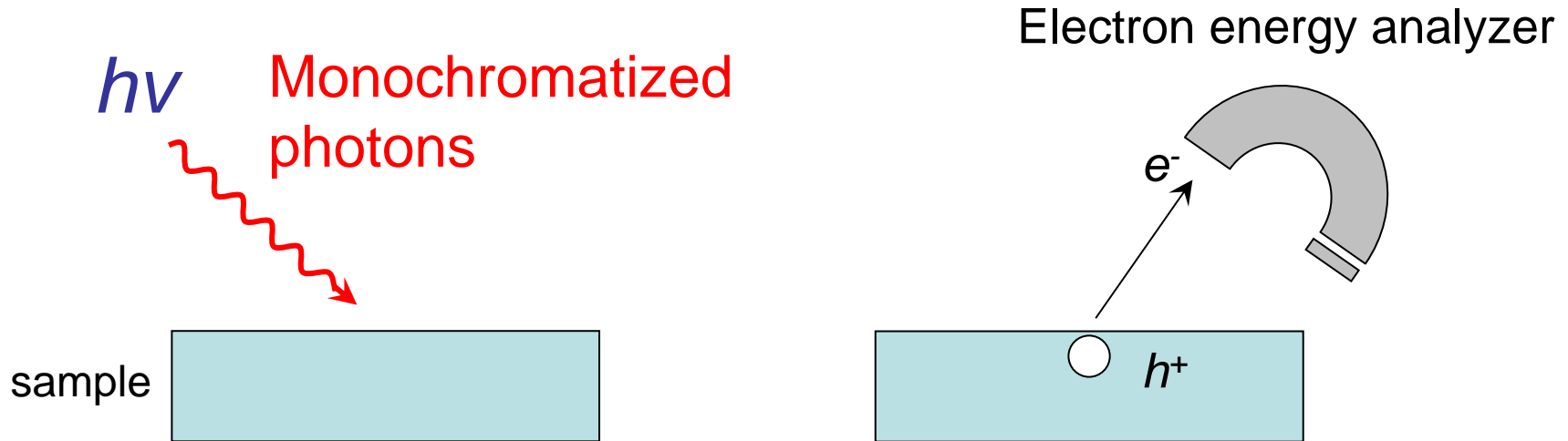
core level states (atomic like)

Solids

valence bands

core level states (atomic like)

What is photoemission spectroscopy? (photoelectron spectroscopy) (PES)



Initial state: ground (neutral) state

Final state: hole (excited) state

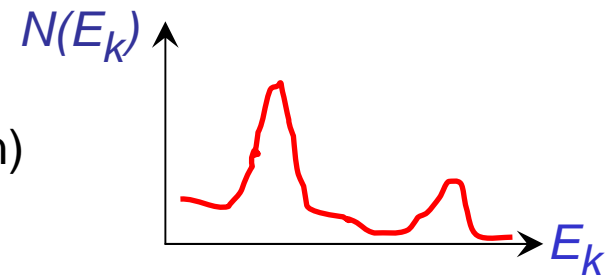
Conservation of energy

$$E_k = h\nu + E_i - E_f \quad (\text{most general expression})$$

E_k : photoelectron kinetic energy

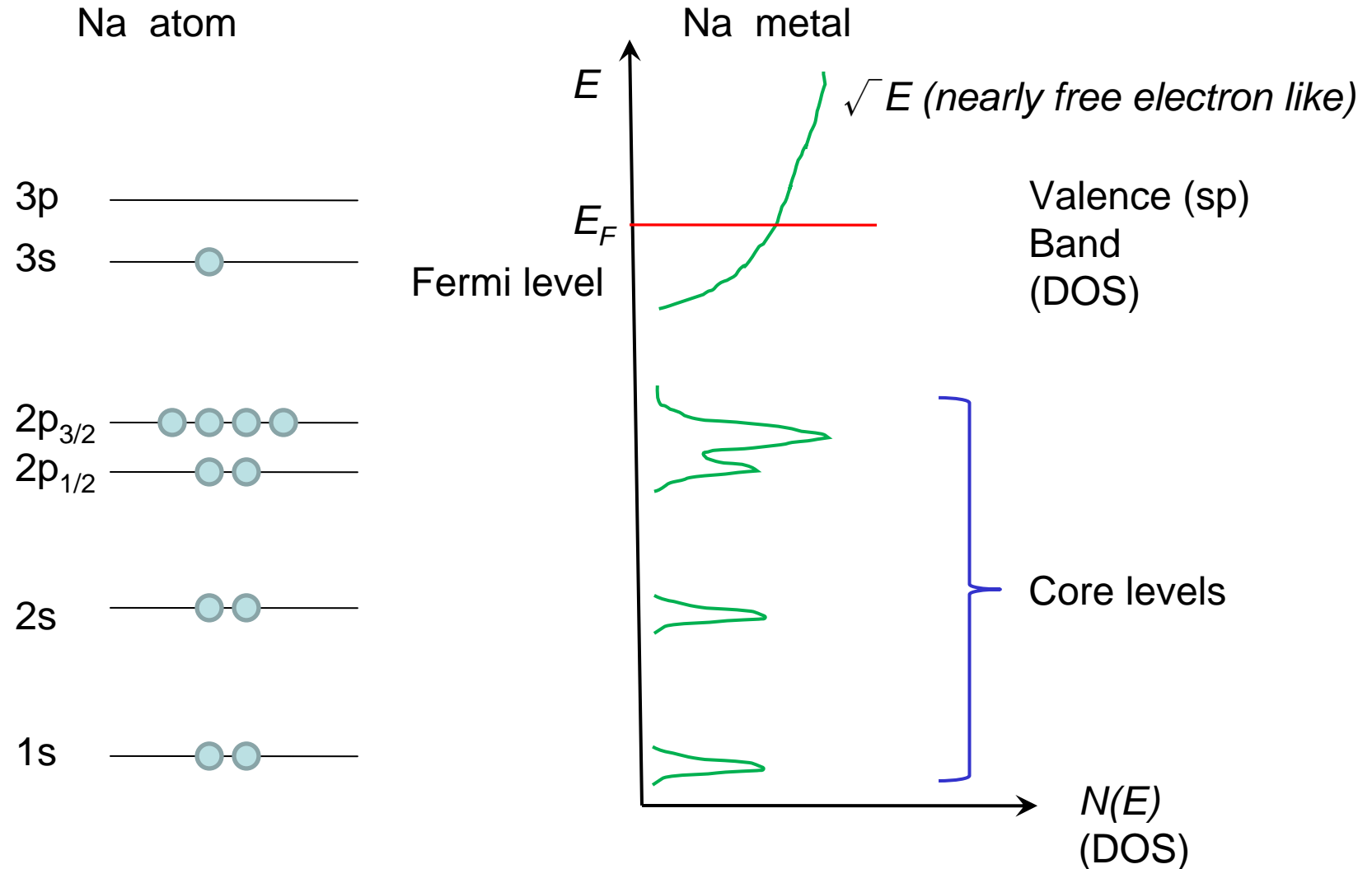
$E_i(N)$: total initial state system energy

$E_f(N-1)$: total final state system energy

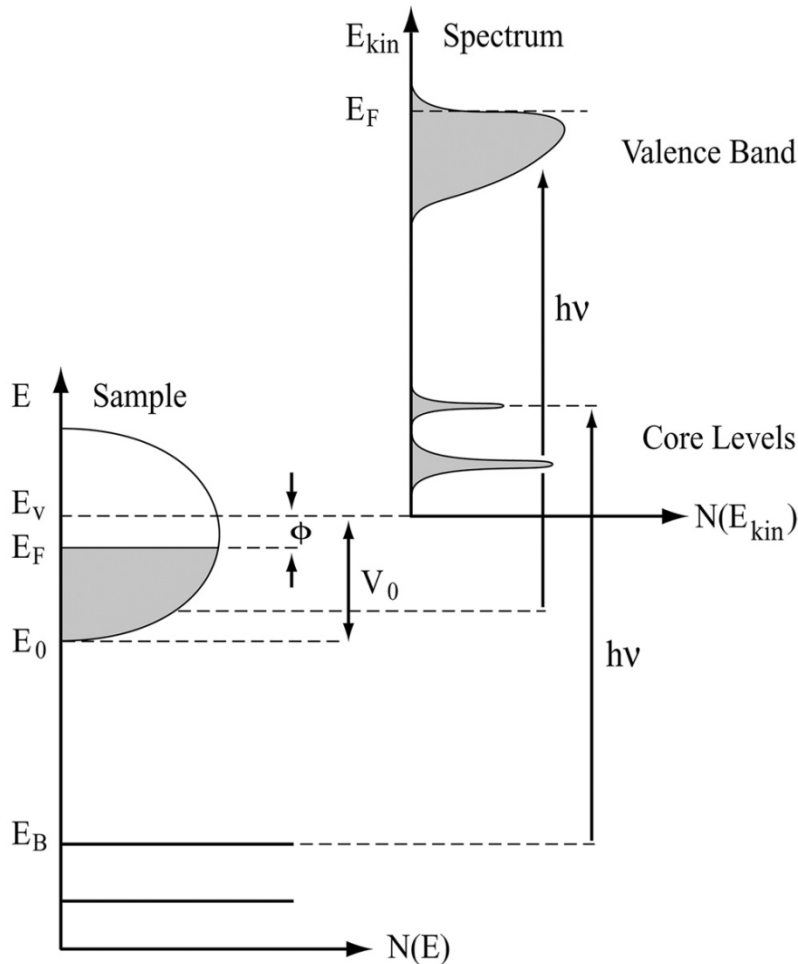


Energy Distribution Curve (EDC)
(Spectrum)

Single particle description of energy levels (Density of States) (most convenient in PE)



Energetics in PES



Hufner, Damascelli

$$E_k = h\nu - E_B - \phi$$

Conservation of energy

E_v : vacuum (energy) level

E_F : Fermi (energy) level

$\phi = E_v - E_F$: work function

E_0 : bottom of valence band

$V_0 = E_v - E_0$: inner potential

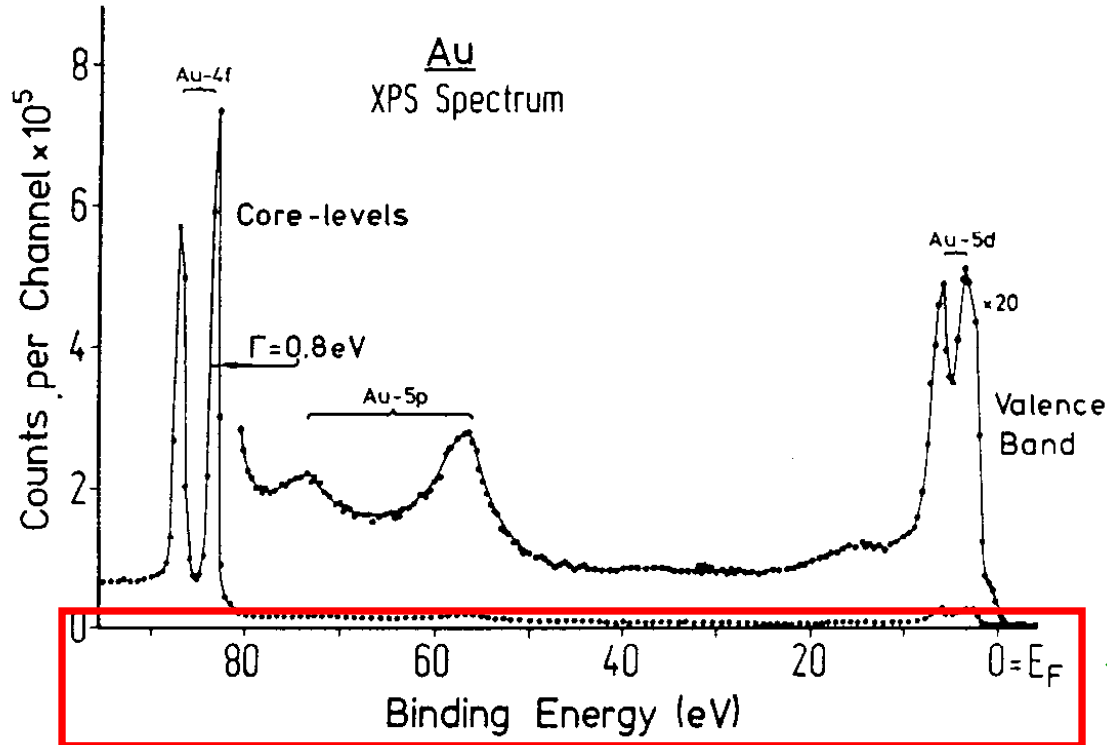
E_k^{max} marks E_F in spectra

E_B measured relative to $E_F = 0$

Usually fixed photon energy

scanning not needed

An XPS Energy Distribution Curve (EDC)



← Most spectra expressed this way

Light sources and terminology

Ultraviolet Photoemission Spectroscopy (UPS)

UV He lamp (21.2 eV, 40.8 eV)

valence band PE, direct electronic state info

X-ray Photoemission Spectroscopy (XPS)

(Electron Spectroscopy for Chemical Analysis) (ESCA)

x-ray gun (Al: 1486.6 eV, Mg: 1253.6 eV)

core level PE, indirect electronic state info

chemical analysis

Synchrotron radiation:

continuous tunable wavelength

valence band: <100 eV, maybe up to several keV

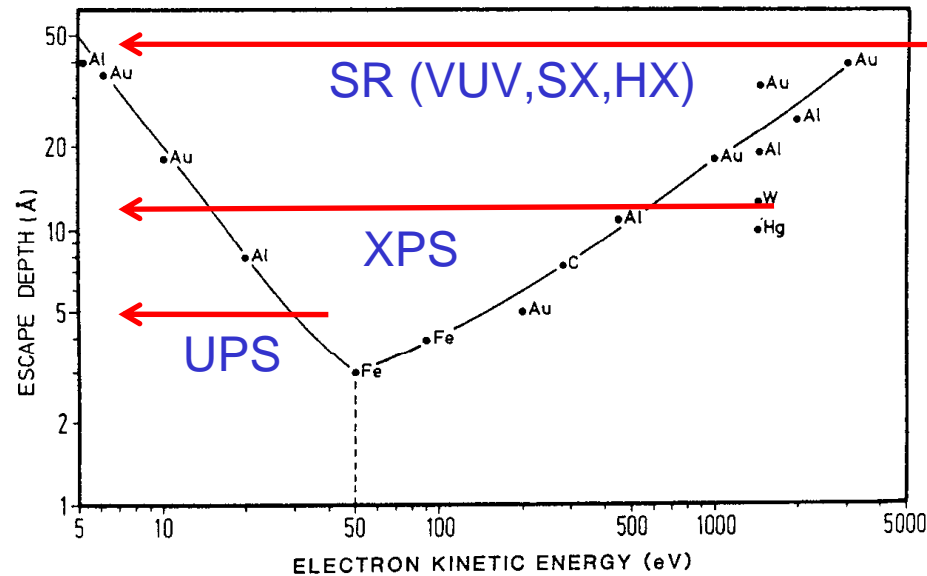
core level: 80-1000 eV, maybe up to several keV

depending on core level binding energies

Inelastic Electron Mean Free Path (IMFP)

$$I(d) = I_0 e^{-d/\lambda(E)}$$

$\lambda(E)$: IMFP depending on kinetic energy relative to E_F



Universal curve

Fig.1.9. Electron escape depth as a function of their kinetic energy for various metals. The data indicate a universal curve with a minimum of $2 \div 5 \text{ \AA}$ for kinetic energies of $50 \div 100 \text{ eV}$. The scatter of the data is evident from the values obtained at $E_{\text{kin}} = 1480 \text{ eV}$

Hufner

Minimum due to electron-electron scattering, mainly plasmons

PE is a surface sensitive technique! (requires UHV)

High energy photoemission: several keV to increase bulk sensitivity

Table 1-1. Electron binding energies, in electron volts, for the elements in their natural forms.

Element	K 1s	L ₁ 2s	L ₂ 2p _{1/2}	L ₃ 2p _{3/2}	M ₁ 3s	M ₂ 3p _{1/2}	M ₃ 3p _{3/2}	M ₄ 3d _{3/2}	M ₅ 3d _{5/2}	N ₁ 4s	N ₂ 4p _{1/2}	N ₃ 4p _{3/2}
1 H	13.6											
2 He	24.6*											
3 Li	54.7*											
4 Be	111.5*											
5 B	188*											
6 C	284.2*											
7 N	409.9*	37.3*										
8 O	543.1*	41.6*										
9 F	696.7*											
10 Ne	870.2*	48.5*	21.7*	21.6*								
11 Na	1070.8†	63.5†	30.65	30.81								
12 Mg	1303.0†	88.7	49.78	49.50								
13 Al	1559.6	117.8	72.95	72.55								
14 Si	1839	149.7* ^b	99.82	99.42								
15 P	2145.5	189*	136*	135*								
16 S	2472	230.9	163.6*	162.5*								
17 Cl	2822.4	270*	202*	200*								
18 Ar	3205.9*	326.3*	250.6†	248.4*	29.3*	15.9*	15.7*					
19 K	3608.4*	378.6*	297.3*	294.6*	34.8*	18.3*	18.3*					
20 Ca	4038.5*	438.4†	349.7†	346.2†	44.3 †	25.4†	25.4†					
23 V	5465	626.7†	519.8†	512.1†	66.3†	37.2†	37.2†					
24 Cr	5989	696.0†	583.8†	574.1†	74.1†	42.2†	42.2†					
25 Mn	6539	769.1†	649.9†	638.7†	82.3†	47.2†	47.2†					
26 Fe	7112	844.6†	719.9†	706.8†	91.3†	52.7†	52.7†					
27 Co	7709	925.1†	793.2†	778.1†	101.0†	58.9†	59.9†					
28 Ni	8333	1008.6†	870.0†	852.7†	110.8†	68.0†	66.2†					
29 Cu	8979	1096.7†	952.3†	932.7	122.5†	77.3†	75.1†					
30 Zn	9659	1196.2*	1044.9*	1021.8*	139.8*	91.4*	88.6*	10.2*	10.1*			
31 Ga	10367	1299.0* ^b	1143.2†	1116.4†	159.5†	103.5†	100.0†	18.7†	18.7†			
32 Ge	11103	1414.6* ^b	1248.1* ^b	1217.0* ^b	180.1*	124.9*	120.8*	29.8	29.2			
33 As	11867	1527.0* ^b	1359.1* ^b	1323.6* ^b	204.7*	146.2*	141.2*	41.7*	41.7*			
34 Se	12658	1652.0* ^b	1474.3* ^b	1433.9* ^b	229.6*	166.5*	160.7*	55.5*	54.6*			
35 Br	13474	1782*	1596*	1550*	257*	189*	182*	70*	69*			
36 Kr	14326	1921	1730.9*	1678.4*	292.8*	222.2*	214.4	95.0*	93.8*	27.5*	14.1*	14.1*
37 Rb	15200	2065	1864	1804	326.7*	248.7*	239.1*	113.0*	112*	30.5*	16.3*	15.3*
38 Sr	16105	2216	2007	1940	358.7†	280.3†	270.0†	136.0†	134.2†	38.9†	21.3	20.1†
39 Y	17038	2373	2156	2080	392.0* ^b	310.6*	298.8*	157.7†	155.8†	43.8*	24.4*	23.1*
40 Zr	17998	2532	2307	2223	430.3†	343.5†	329.8†	181.1†	178.8†	50.6†	28.5†	27.1†
41 Nb	18986	2698	2465	2371	466.6†	376.1†	360.6†	205.0†	202.3†	56.4†	32.6†	30.8†
42 Mo	20000	2866	2625	2520	506.3†	411.6†	394.0†	231.1†	227.9†	63.2†	37.6†	35.5†
43 Tc	21044	3043	2793	2677	544*	447.6	417.7	257.6	253.9*	69.5*	42.3*	39.9*
44 Ru	22117	3224	2967	2838	586.1*	483.5†	461.4†	284.2†	280.0†	75.0†	46.3†	43.2†
45 Rh	23220	3412	3146	3004	628.1†	521.3†	496.5†	311.9†	307.2†	81.4* ^b	50.5†	47.3†
46 Pd	24350	3604	3330	3173	671.6†	559.9†	532.3†	340.5†	335.2†	87.1* ^b	55.7† ^a	50.9†
47 Ag	25514	3806	3524	3351	719.0†	603.8†	573.0†	374.0†	368.3	97.0†	63.7†	58.3†

Core level binding energies are characteristic of each orbital of each element

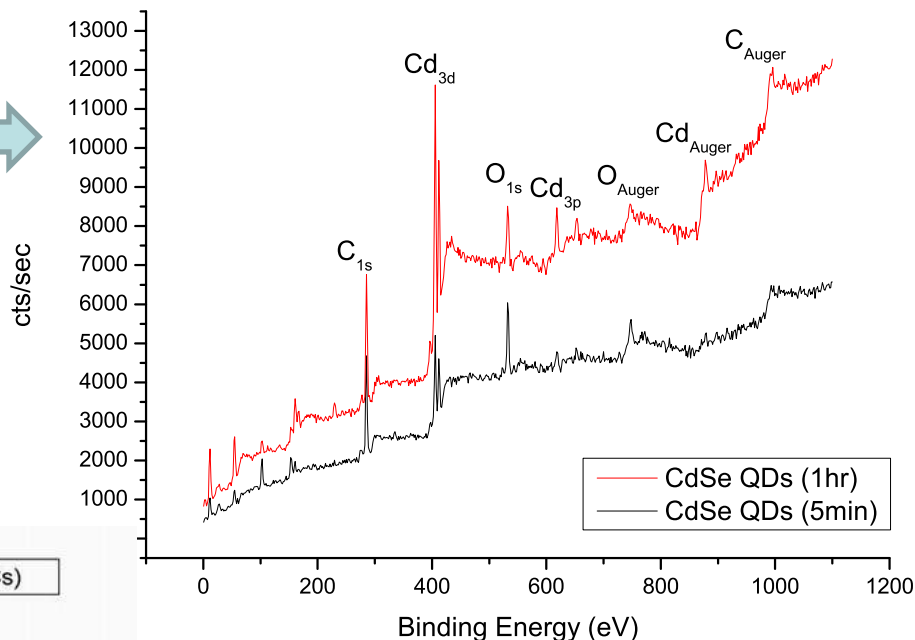
Finger prints

Core level BE independent of photon energy used

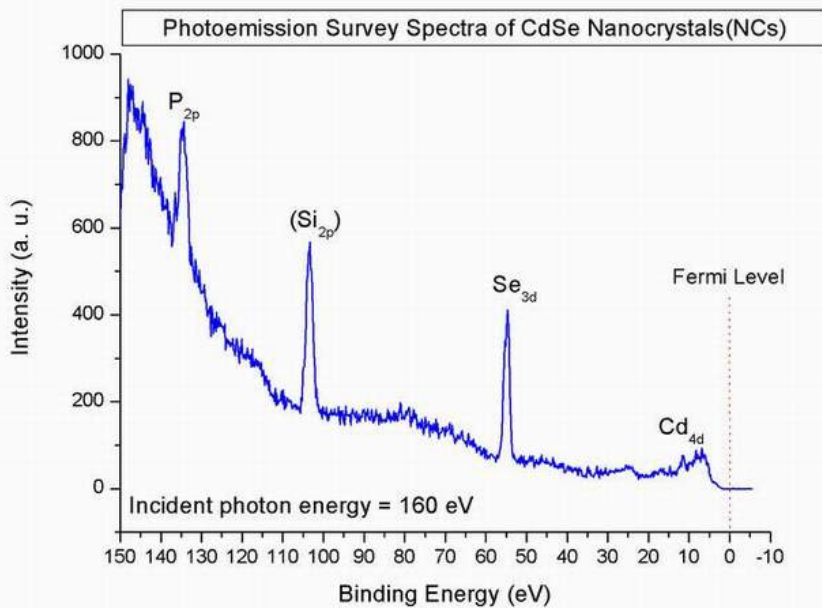
Core level photoemission: chemical analysis of elements

ESCA (XPS)

$h\nu = \text{Mg } K\alpha = 1253.6 \text{ eV}$

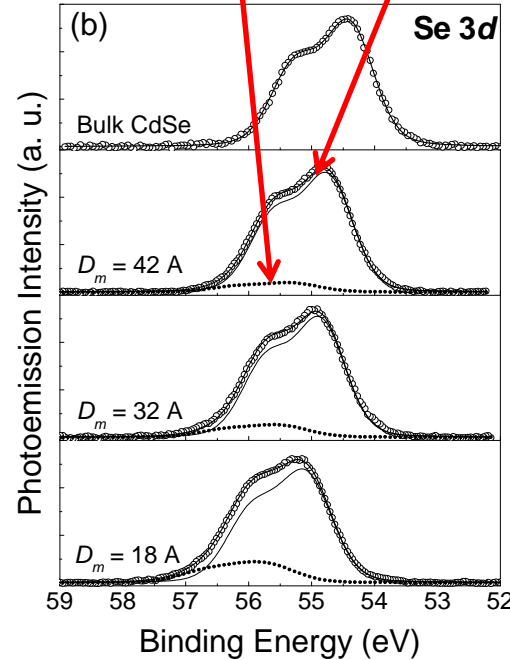
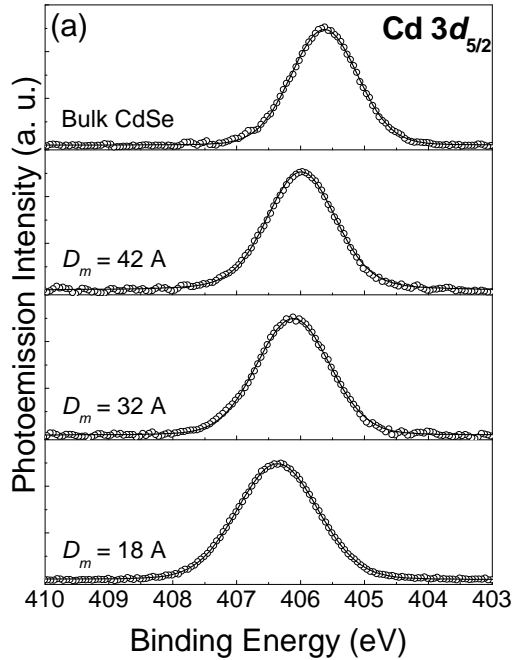


Synchrotron $h\nu = 160 \text{ eV}$



Different photon energy \rightarrow
different relative cross section
for various core levels \rightarrow
Relative intensity changes
with photon energy

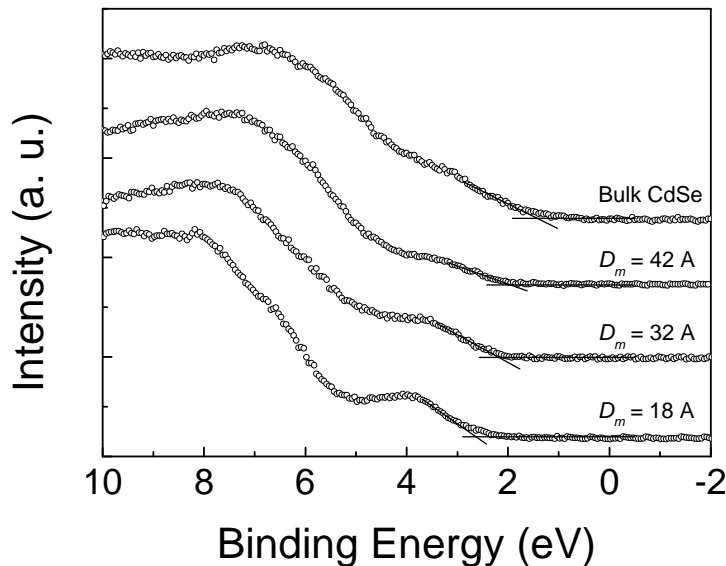
surface component bulk component



Surface core level shift
(chemical and/or environmental)

A case study of IMFP applied to PE of CdSe nano particles with tunable SR

How to choose photon energies for valence and different core levels with the max surface sensitivity?



Actual choices:

Cd $3d_{5/2}$: 480 eV

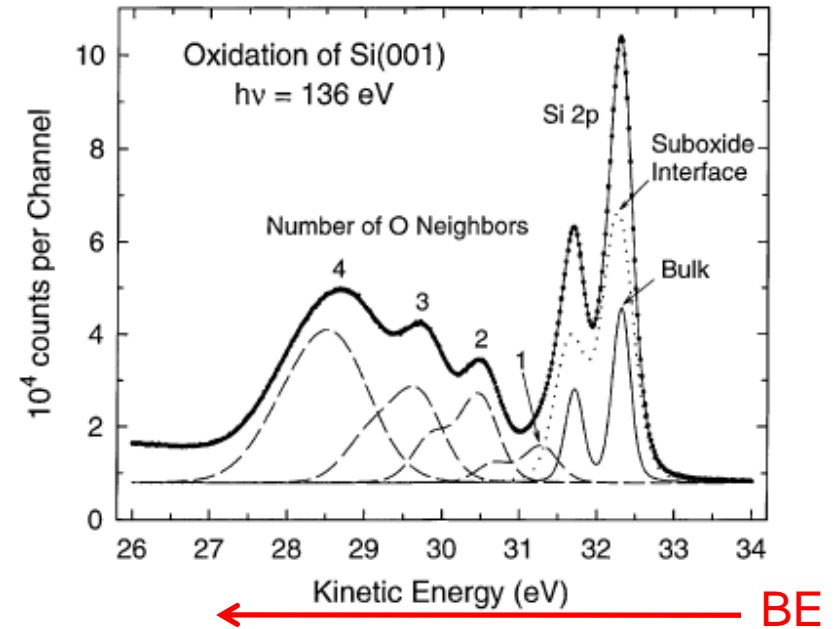
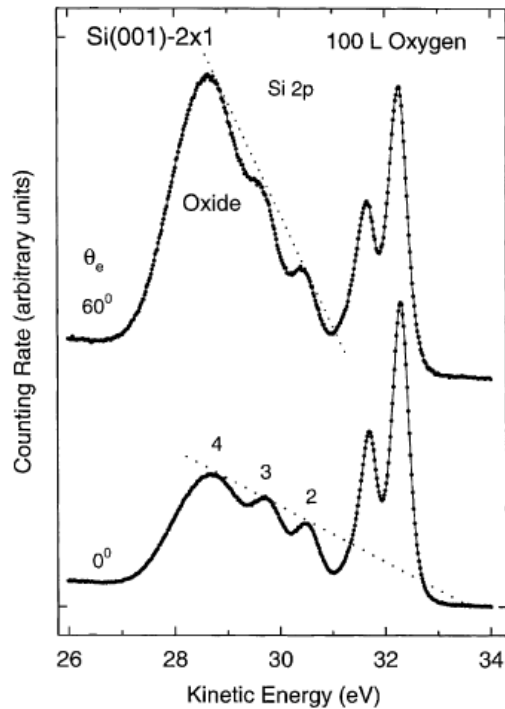
Se $3d$: 120 eV

Valence band: 50 eV

$E_k \sim 45-74 \text{ eV}$, most surface sensitive

Core level photoemission: chemical shift

higher oxidation state
=> higher BE



higher emission angle
→ more surface sensitive
(IMFP) Pi, SS 2001 NSRRC

Auger Electron Spectroscopy

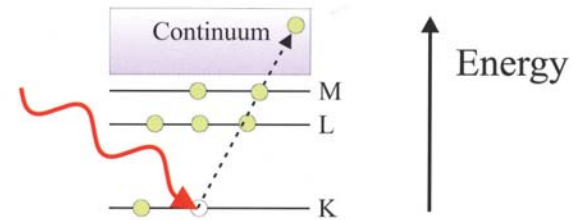
Core electron ionized by photons
or high energy electrons
Non-radiative core hole decay
→ Auger electron emission
Radiative decay
→ Fluorescent x-ray emission

Comparison between PES
and AES

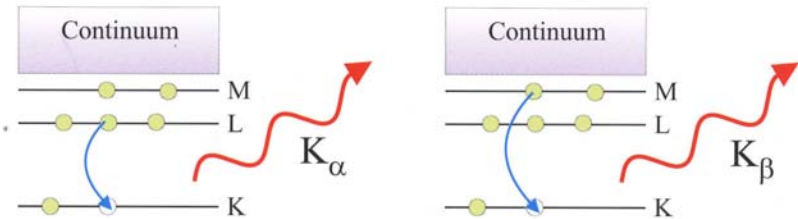
PES: constant BE, E_k shift
with changing photon energy

AES: constant E_k , apparent
BE shift with changing
photon energy
(synchrotron)

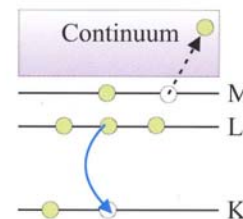
(a) Photoelectric absorption



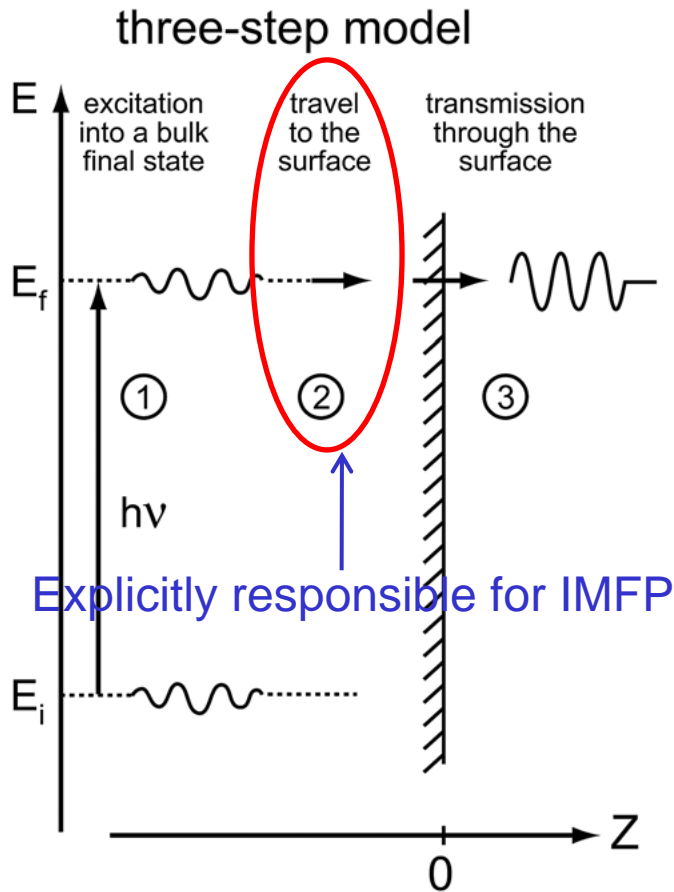
(b) Fluorescent X-ray emission



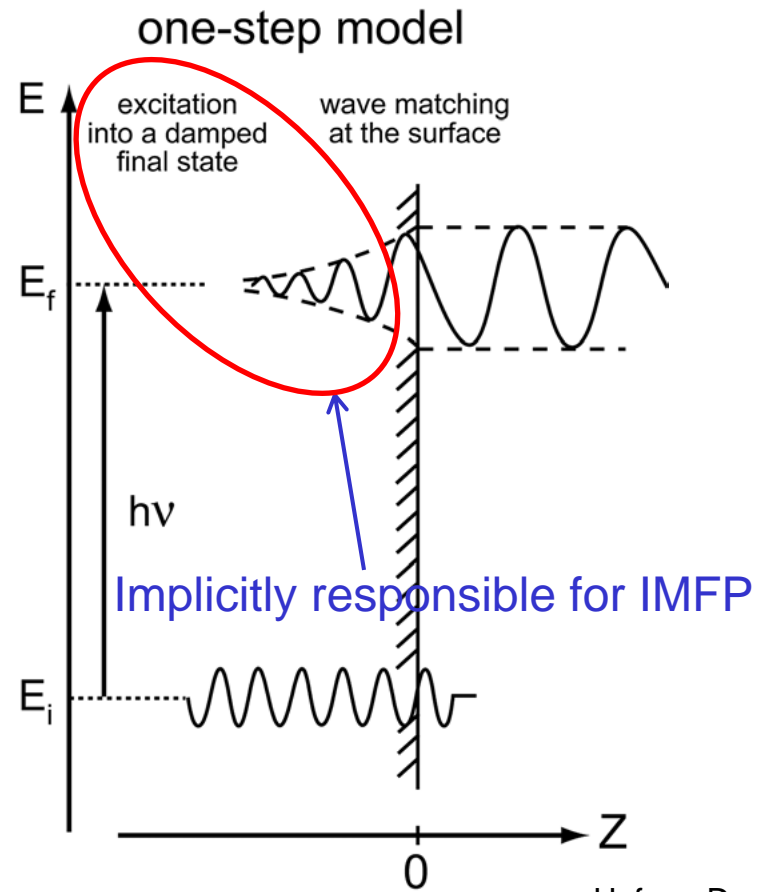
(c) Auger electron emission



Photoemission Process

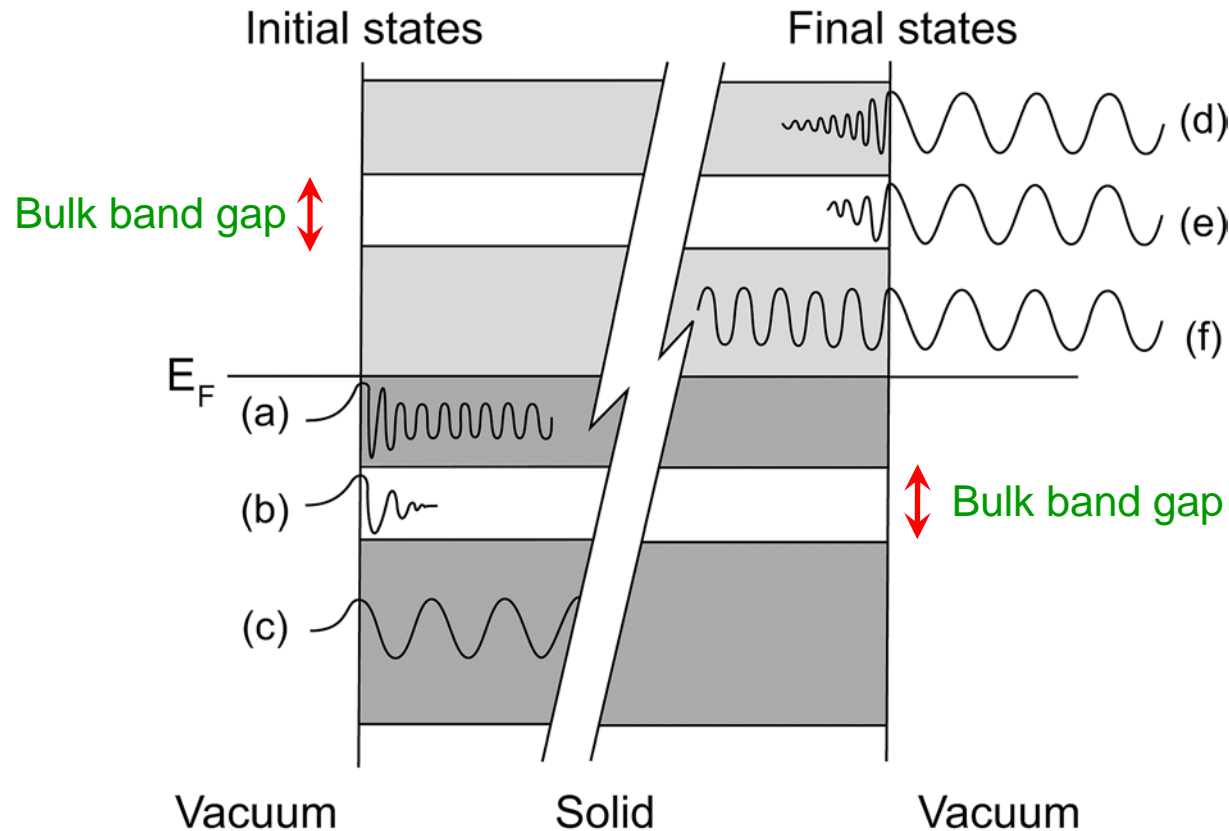


Conceptually intuitive,
Simple calculation works



Rigorous,
requires sophisticated calculation

Schematic wave functions of initial and final states (valence band initial states)

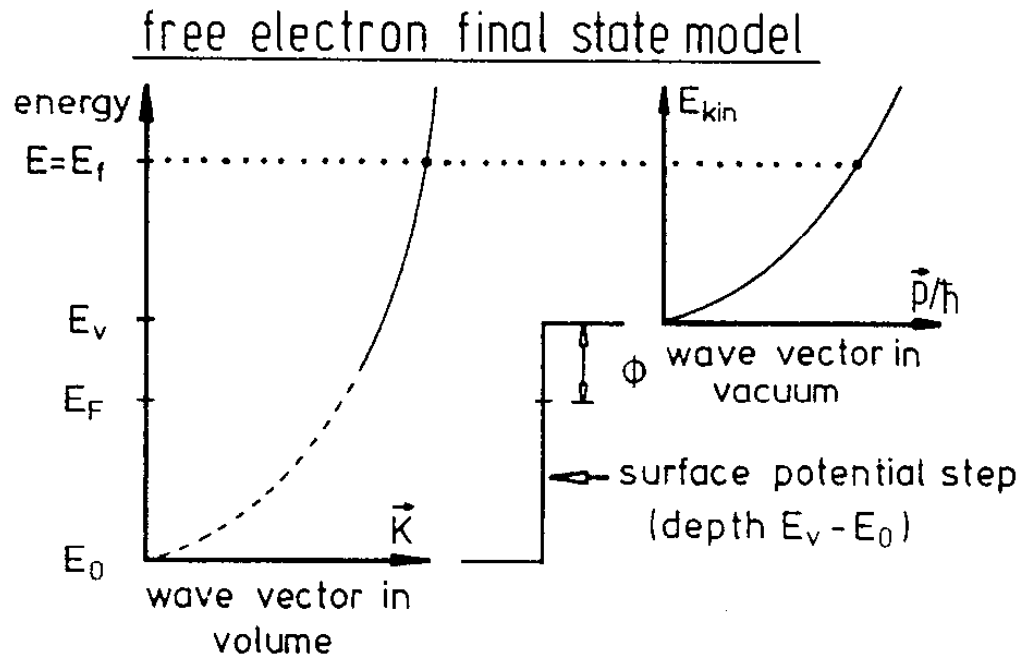


- (a) Surface resonance
- (b) Surface state
- (c) Bulk Bloch state

- (d) Surface resonance
- (e) in-gap evanescent state
- (f) Bulk Bloch final state

Electron kinetic energy inside and outside of solids

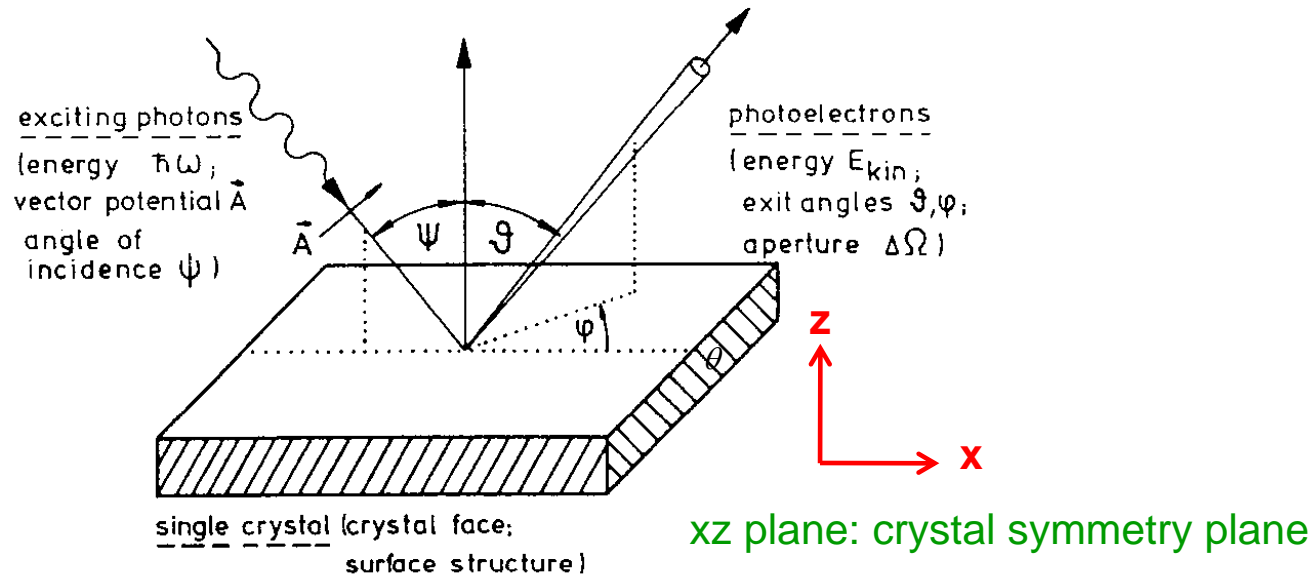
Inner potential: $E_V - E_0$



Concept of inner potential is used to deduce 3D band structure from PE data assuming free electron like final state inside solids

Angle Resolved Photoemission Spectroscopy (ARPES)

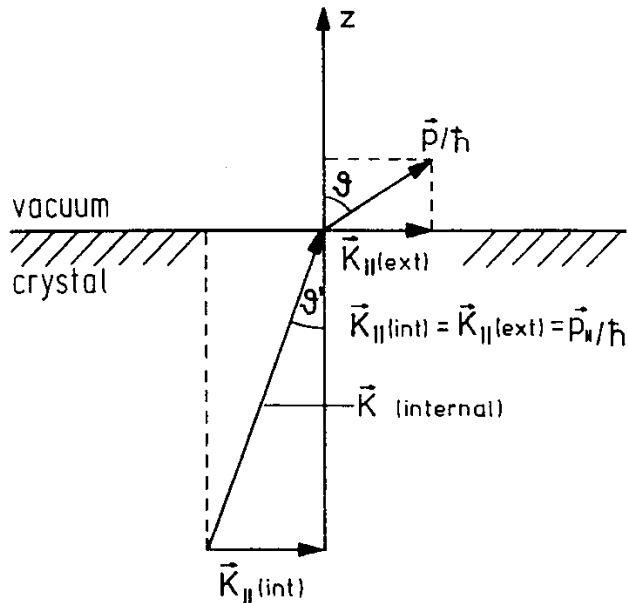
Angular Resolved Photoemission Spectroscopy (ARPES)



Electron emission angle: θ

Photon incident angle: ψ , s- and p-polarization

Conservation of linear momentum parallel to the surface



$$k_{\parallel} = \sqrt{\frac{2m}{\hbar^2} E_k} \cdot \sin \theta$$

$$k_{\parallel} (\text{\AA}^{-1}) = 0.5123 \sqrt{E_k (eV)} \cdot \sin \theta$$

$$k_{\parallel}(\text{inside}) = k_{\parallel}(\text{outside})$$

Conservation of linear momentum

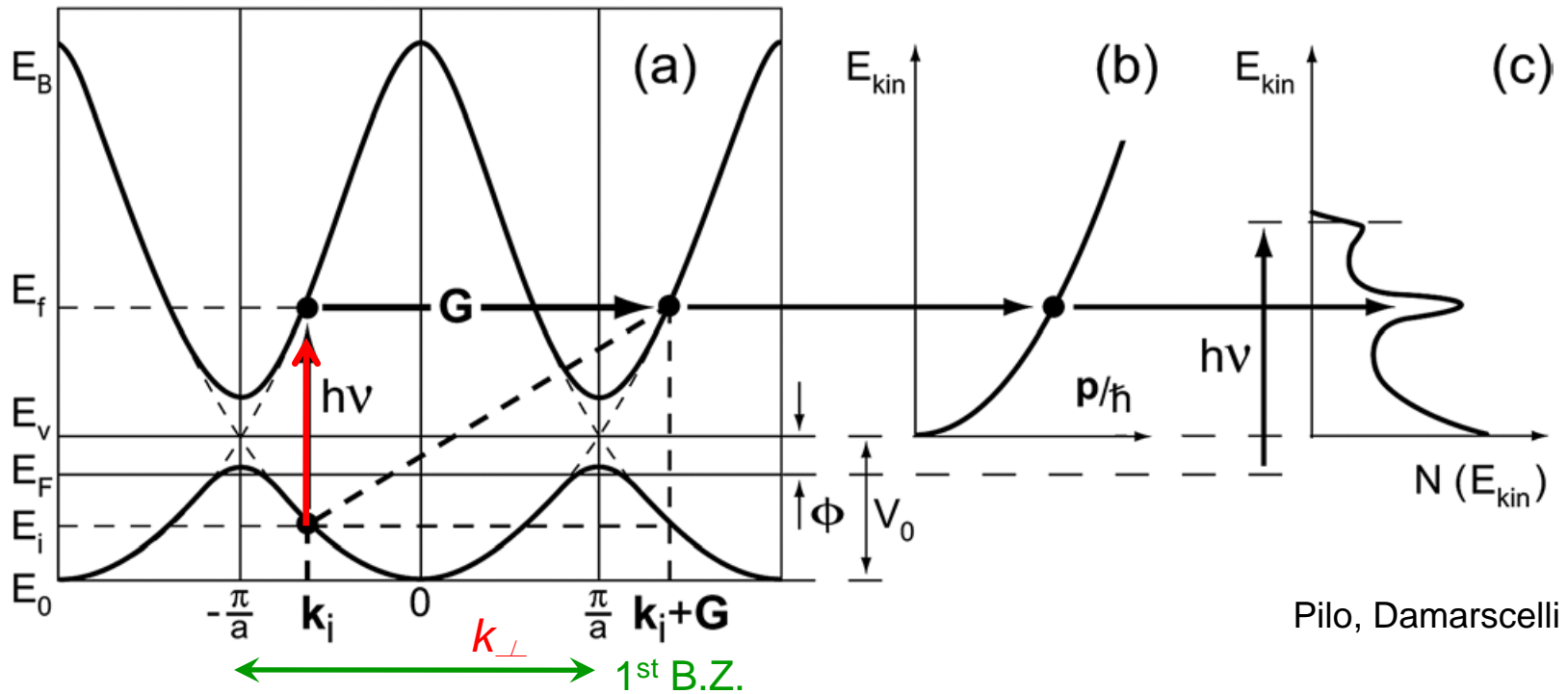
Important for 3D and 2D band mapping

$k_{\perp}(\text{inside}) \neq k_{\perp}(\text{outside})$ because of inner potential

Ultimately to deduce **band dispersion** $E(k_{\perp})$ or $E(k_{\perp}, k_{\parallel})$

Normal emission: $\theta = 0$, or $k_{\parallel} = 0$, most used detection geometry

Band Mapping (3D) $E(k_{\perp}, k_{\parallel}=0)$



Pilo, Damarcelli

Vertical transition (using visible, uv and soft x-rays) at normal emission

For hard x-ray photon momentum cannot be neglected

Using different $h\nu$ at normal emission to map out $E(k_{\perp})$

Bulk band structure and Fermi surfaces

Fermi surfaces:

Electron pockets and hole pockets

Related to

Hall coefficient

Electric conductivity

Magnetic susceptibility

Cu

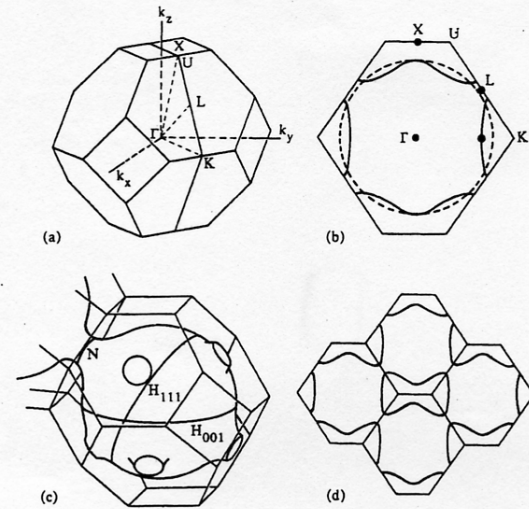


Fig. 10-15 Various aspects of the Fermi surface of Cu. (a) The Brillouin zone of an fcc lattice with some special points labeled. (b) A (110) section of the Brillouin zone. See the text for the meaning of the internal curves. (c) The proposed Fermi surface of Cu. (d) The extended zone picture of a (110) section of the Fermi surface showing the dog bone orbits.

Gap below $E_F (=0)$ at L-point

(nearly free electron like) sp -band

Small dispersion d -band
more localized state

Large dispersion sp -band
extended state

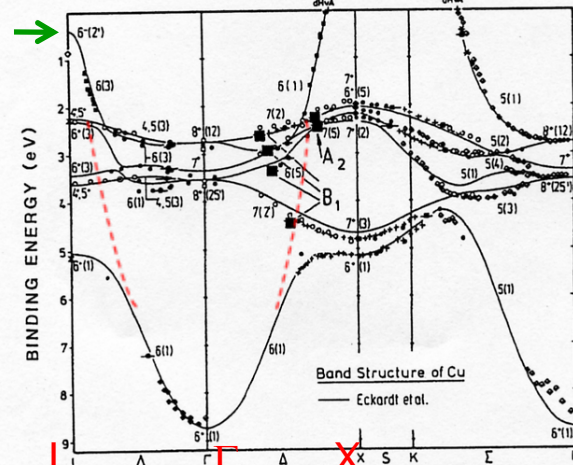


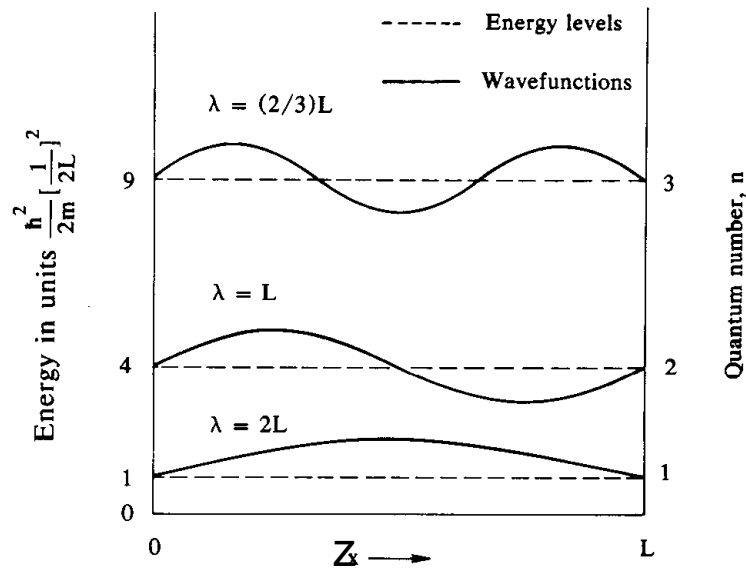
Fig. 7.17. Occupied part of the band structure of Cu [7.39] with data points from various sources and a theoretical result [7.53]. Also shown (squares) are the two A_2 points and the four B_1 points from Fig. 7.16

(111) ← → (001)

Hufner

Dispersion of a band can tell how localized or extended a state is in a solid

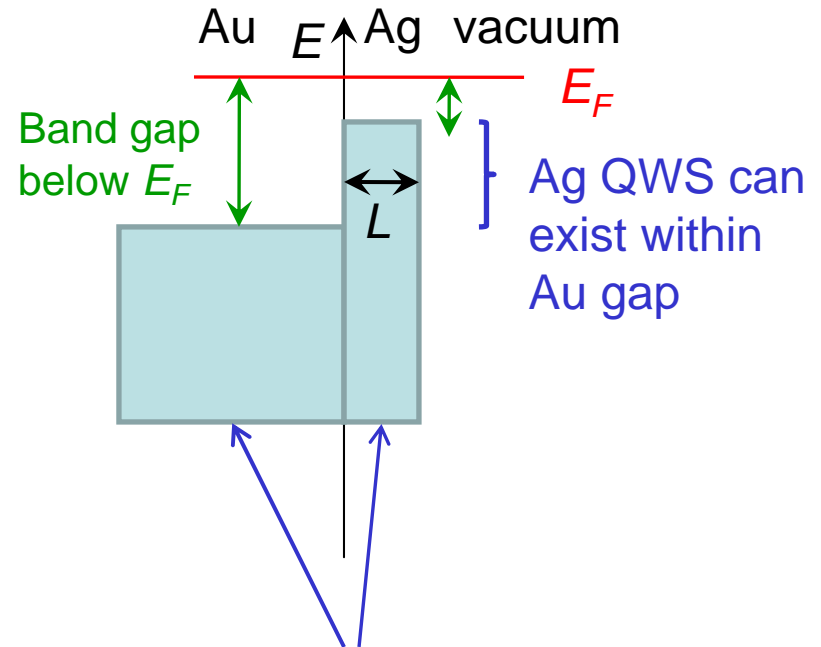
Quantum well states: manifestation of particle in a box in real materials



Quantized discretely along z-direction
Energy levels depend on film thickness L

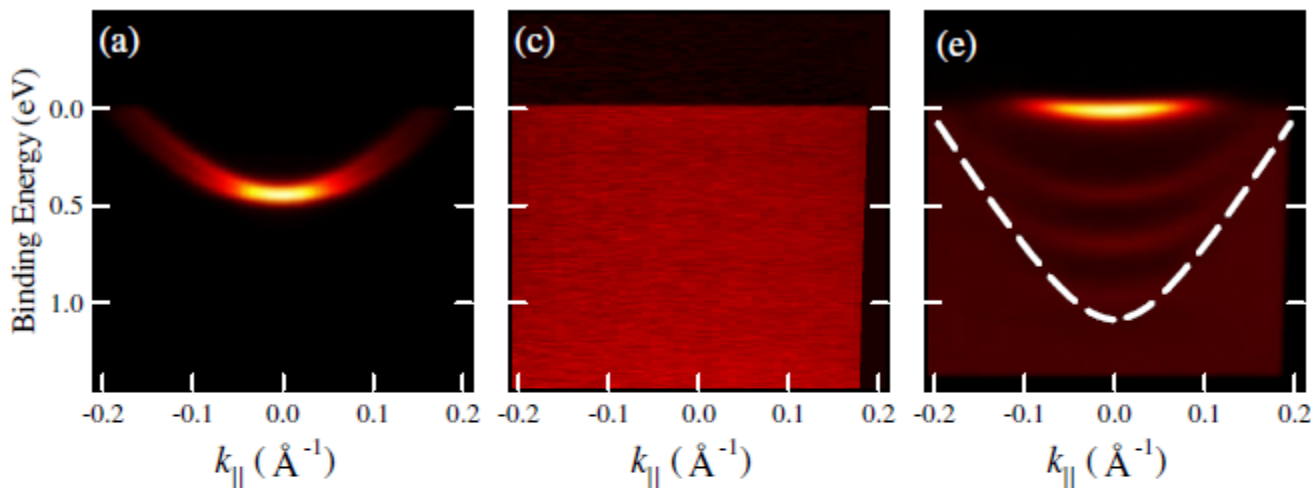
Nearly free electron like in xy-plane

Ag(111) thin films epitaxially grown on Au(111) substrate



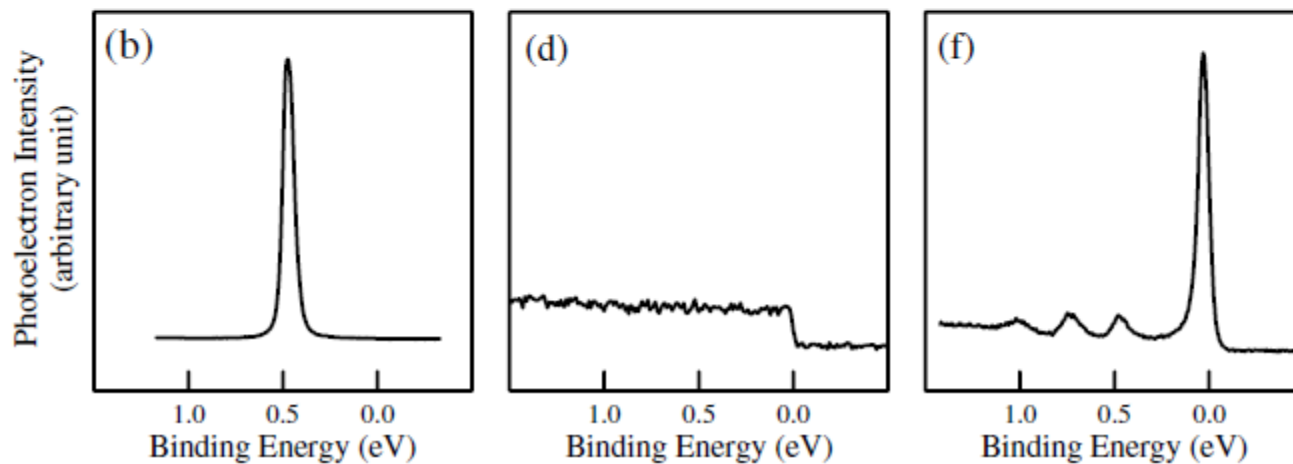
Bulk projected bands along ΓL of Au and Ag, respectively

2D
Int.
plots



← Ag S.S.
Ag QWS

$k_{\parallel} = 0$
EDCs

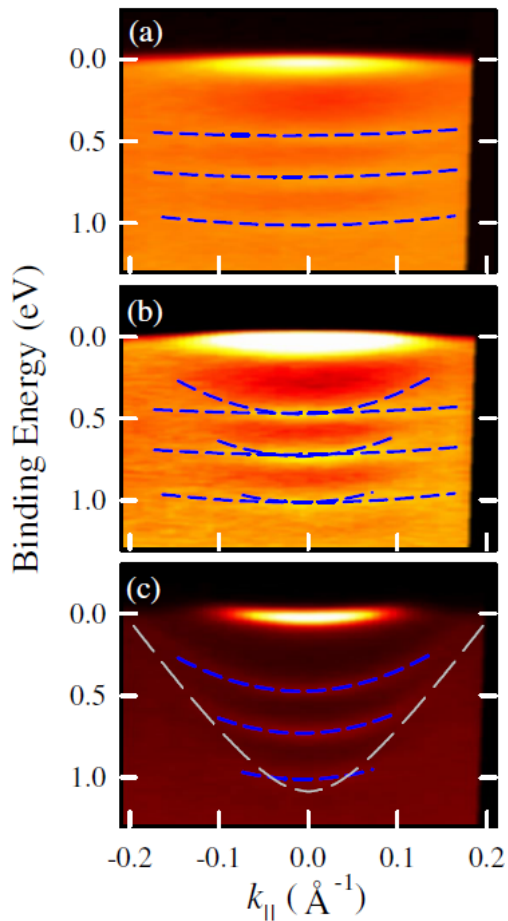


Luh et al.
PRL 2008
NSRRC
BL21B1

Clean Au(111)
surface state

Deposit 22 ML Ag
at 37 K
disordered form

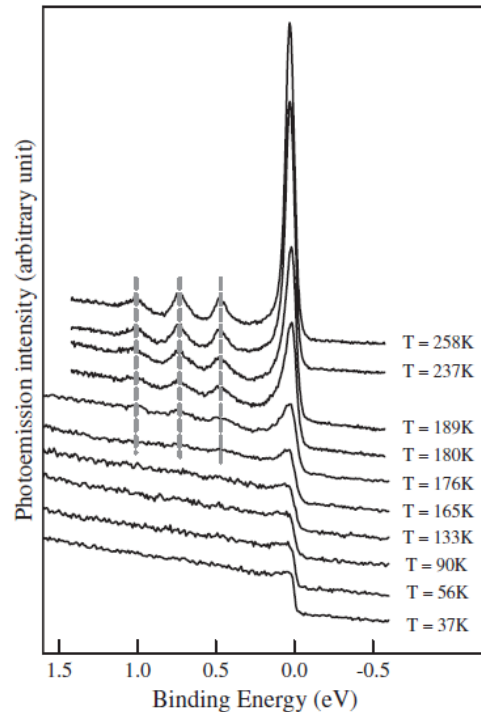
Anneal to 258 K
Atomically flat
22 ML thin film



Anneal to 180 K
 QWS appear
 minimal flat
 dispersion
 Small localized
 domains within
 xy-plane

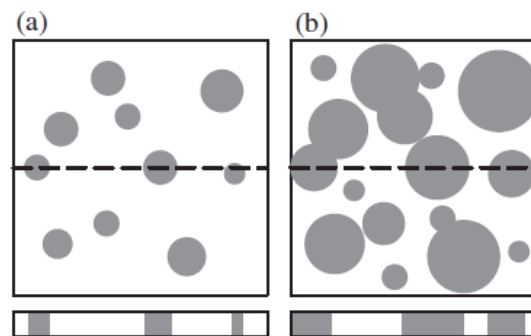
Anneal to 189 K
 Coexistence of
 two kinds of
 dispersion

Anneal to 258 K
 Well developed
 dispersion
 Large, good
 crystalline
 domains
 in xy-plane



Same QWS energies →
 Same crystalline film
 thickness along z
 even though lateral
 crystalline domains
 grow from small to
 large

Proposed growth model



Annealing Temp →

One-particle spectral function near E_F measured by ARPES with many-particle correction (quasi-particle)

$$A(k, \omega) = -\frac{1}{\pi} \frac{\Sigma''(k, \omega)}{[\omega - \varepsilon_k - \Sigma'(k, \omega)]^2 + [\Sigma''(k, \omega)]^2}$$

ε_k : single particle energy without many-particle correction

$\omega = 0$: E_F

Self energy correction due to interaction with phonons, plasmons and electrons, etc.

$$\Sigma(k, \omega) = \Sigma'(k, \omega) + i\Sigma''(k, \omega)$$

Real part: shift observed peak energy from single particle energy

Imaginary part: peak FWHM = $2 \Sigma''$

Many-Body Effects in Angle-Resolved Photoemission: Quasiparticle Energy and Lifetime of a Mo(110) Surface State

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²*National Synchrotron Light Source, Brookhaven National Laboratory, Upton, New York 11973-5000*

(Received 28 January 1999)

In a high-resolution photoemission study of a Mo(110) surface state various contributions to the measured width and energy of the quasiparticle peak are investigated. Electron-phonon coupling, electron-electron interactions, and scattering from defects are all identified mechanisms responsible for the finite lifetime of a valence photohole. The electron-phonon induced mass enhancement and rapid change of the photohole lifetime near the Fermi level are observed for the first time.

Peak position

Kink ~25 meV due to electron-phonon scattering

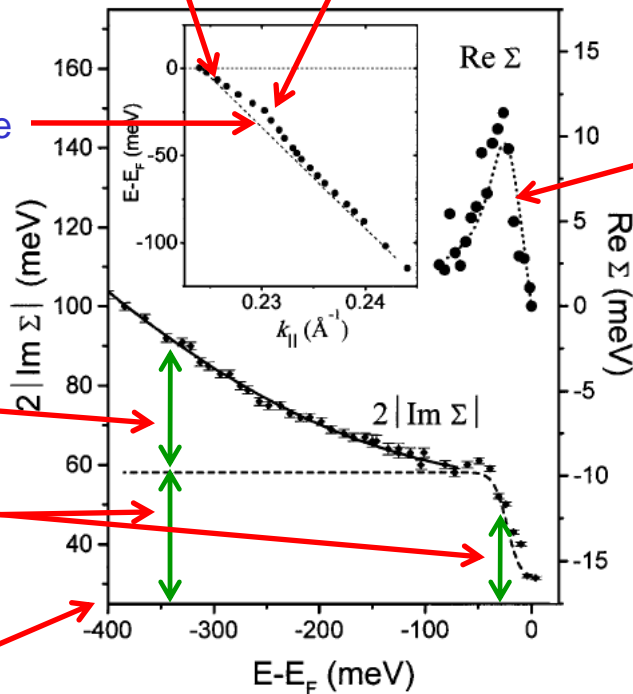
Featureless single particle dispersion curve

Peak position – single particle curve

Width due to electron-electron scattering $\sim \omega^2$

Width due to electron-phonon scattering

Const bkg width due to impurities



$$\text{Total } W = W_{e-e} + W_{e-ph} + W_{im}$$

Photoemission cross section in single particle approximation (1st step in 3-step model, inside bulk)

$$\frac{d\sigma}{d\Omega} \propto \sum \left| \langle \Psi_f | A \cdot p | \Psi_i \rangle \right|^2 \cdot \delta(E_f - E_i - h\nu)$$

$$M_{fi} = \langle \Psi_f | A(r) \cdot p | \Psi_i \rangle \cong A(0) \cdot \langle \Psi_f | p | \Psi_i \rangle \propto A(0) \cdot \langle \Psi_f | r | \Psi_i \rangle$$

dipole approximation

A : polarization vector

Ψ_i : initial state (orbital) wave function (1s, 2p, valence states etc.)
contain orbital symmetry information

Ψ_f : final state (orbital) wave function $\sim \exp(i\mathbf{k}\mathbf{r})$ for high kinetic energy
photoelectrons, no orbital symmetry retains (non-resonance photoemission)

(orbital symmetry in final state is important in near edge absorption
measurements (XAS) and in intermediate state in resonance photoemission)

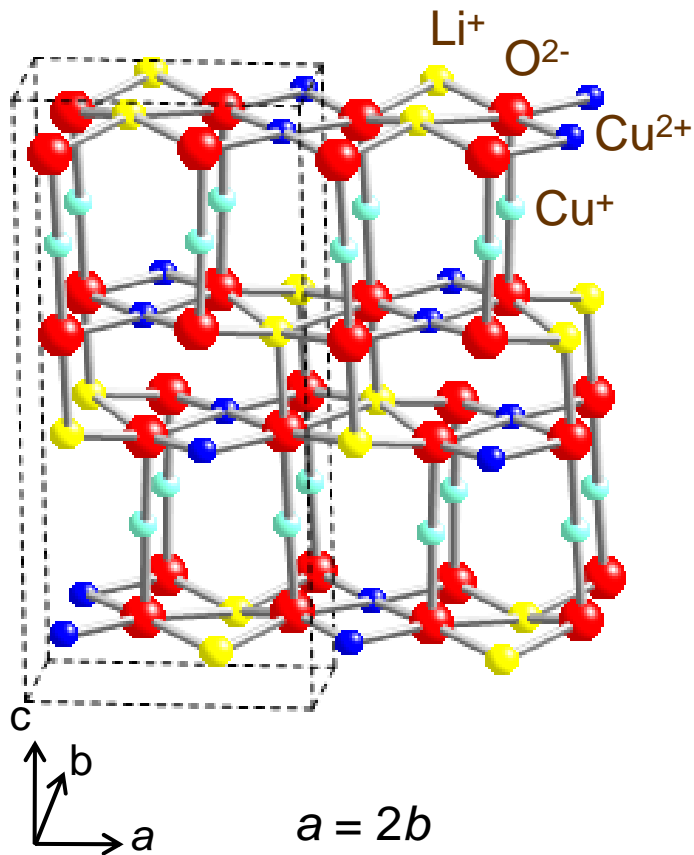
Dipole transition rule: $\Delta l = \pm 1$

Symmetry selection rule for initial (valence) state governed by matrix element

e.g. suppose $A(0) = Ax$, $\langle e^{ikz} | x | \psi_i(x) \rangle = 0$ if $\psi_i(-x) = +\psi_i(x)$

Important for crystalline samples

Symmetry of states in ARPES determined by selection rule example: LiCu₂O₂



Cu²⁺O₂²⁻ chains along b-axis built by edge sharing Cu²⁺O₄²⁻ plaquettes

Cu²⁺ : 3d⁹ → spin-1/2

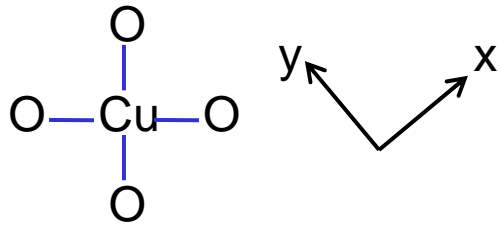
Quasi-1D spin-1/2 chain

Coexistence of spin-spiral long range order with ferroelectricity → multiferronic

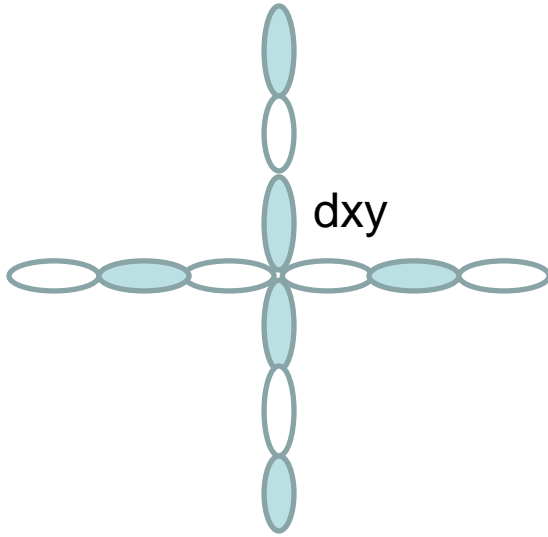
Ideal spin-1/2 1D chain system will have spin-charge separation of photo-hole decay
Does it happen on LiCu₂O₂?

Must be checked by ARPES
(not discussed further)

Will focus on symmetry of states determined by ARPES with polarization



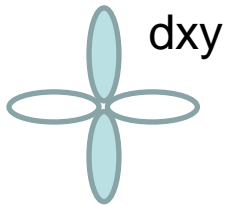
Basic building unit: CuO₄ planar plaquette



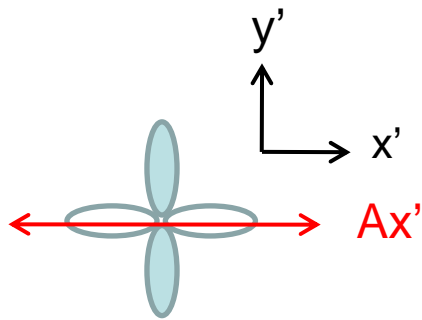
dxy

Highest energy state:
Cu 3dxy and O 2p antibonding (AB) state

Still keeps dxy symmetry

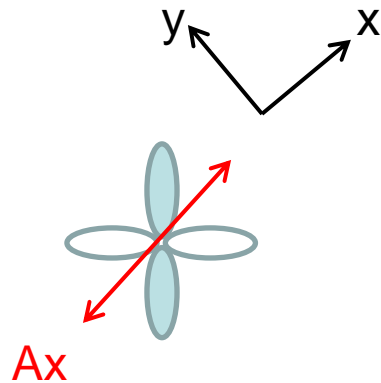


dxy



Normal emission $|f\rangle = \exp(ikz)$ even to all symmetry op
 $|i\rangle$ even to $y'z$ -plane, Ax' odd to $y'z$ -plane
 $\langle f| Ax' |i\rangle = \langle +| - | +\rangle = 0$, **forbidden**

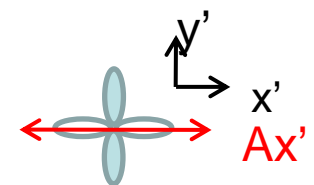
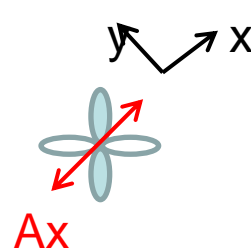
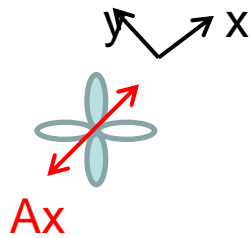
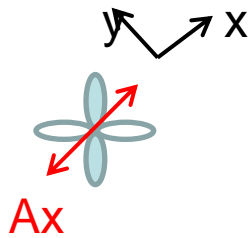
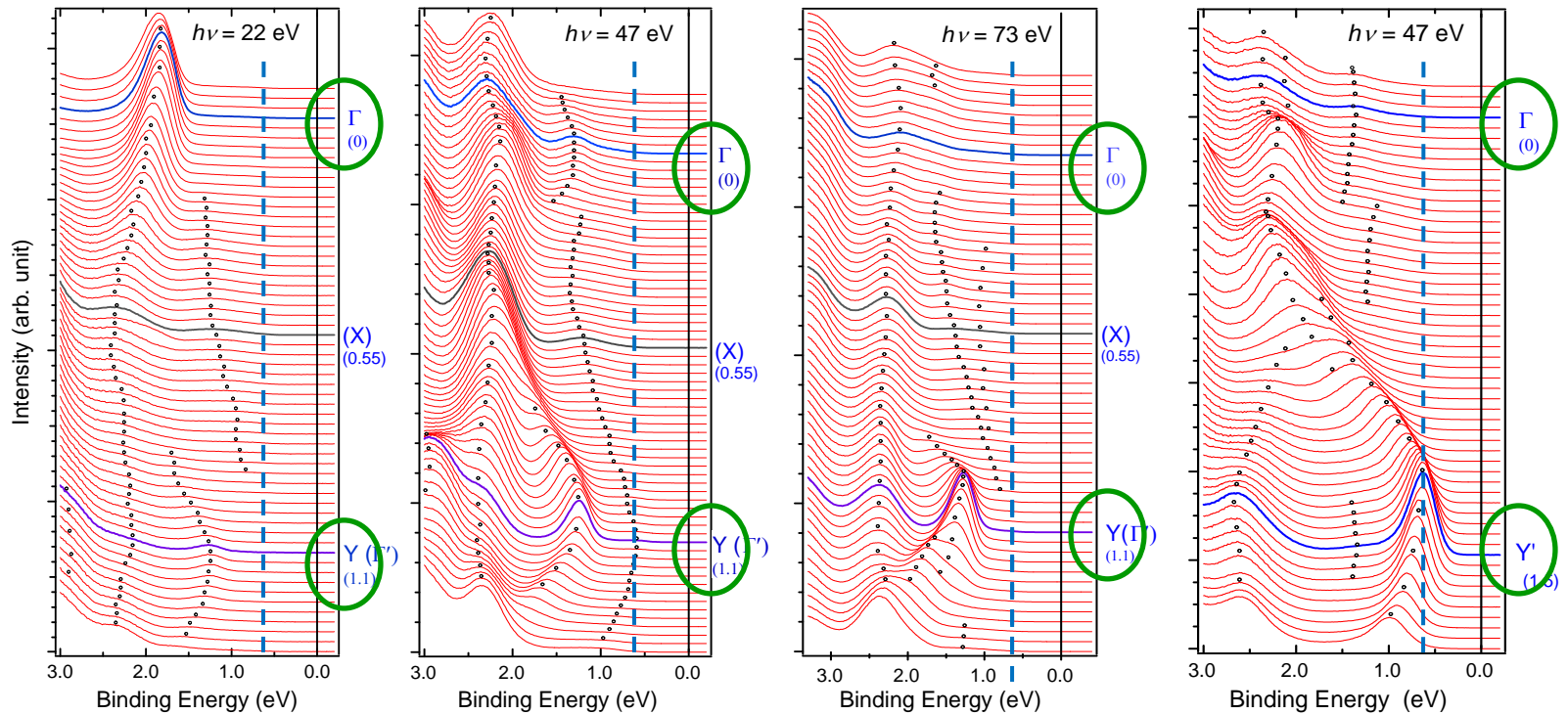
Off-normal emission $|f\rangle = \exp(ikz+kx')$ even to $x'z$ -plane
 $|i\rangle$ even to $x'z$ -plane, Ax' even to $x'z$ -plane
 $\langle f| Ax' |i\rangle = \langle +| + | +\rangle \neq 0$, **allowed**



Normal emission $|f\rangle = \exp(ikz)$ even to all symmetry op
 $|i\rangle$ odd to xz -plane, Ax even to xz -plane
 $\langle f| Ax |i\rangle = \langle +| + | -\rangle = 0$, **forbidden**

Off-normal emission $|f\rangle = \exp(ikz+ikx)$ even to xz -plane
 $|i\rangle$ odd to xz -plane, Ax even to xz -plane
 $\langle f| Ax |i\rangle = \langle +| + | -\rangle = 0$, **forbidden**

Focus on B.E. = 0.7 eV peak at Y'



The highest energy peak at 0.7 eV has d_{xy} symmetry!

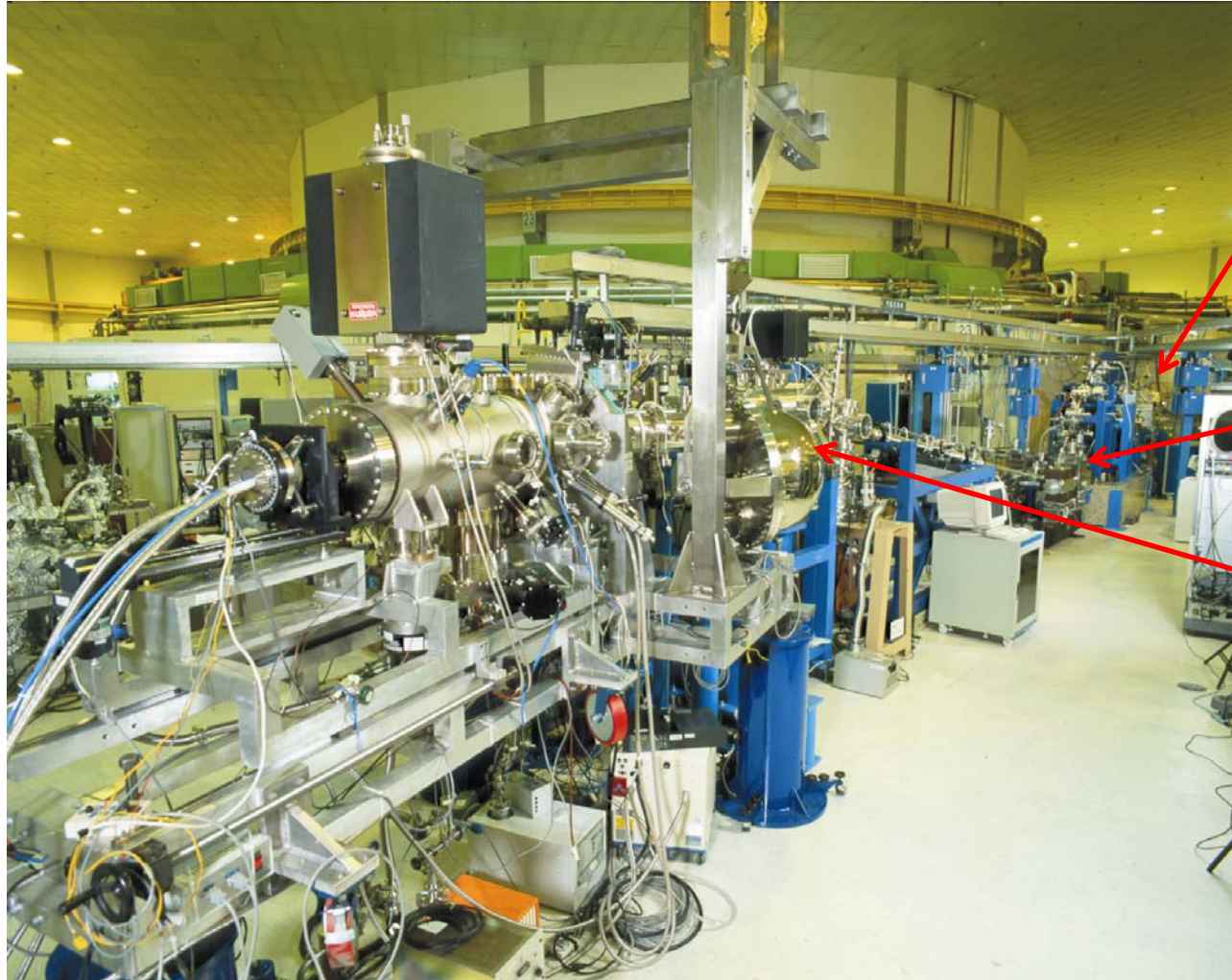
ARPES for valence band PE uses primarily VUV light because

1. Better absolute photon energy resolution for most BLs designed as const $\Delta E/E$.
2. Better photoionization cross section at low photon energy.
3. Better momentum resolution for a given angular resolution.

$$\Delta k_{||} = 0.5123 \sqrt{E_k} \cos(\theta) \Delta\theta$$

SX ARPES has been tried for increasing bulk sensitivity, more free electron like final states and reduced matrix element effects. The increasing bulk sensitivity will be discussed.

NSRRC U9 BL21B1 BL and high resolution photoemission end station

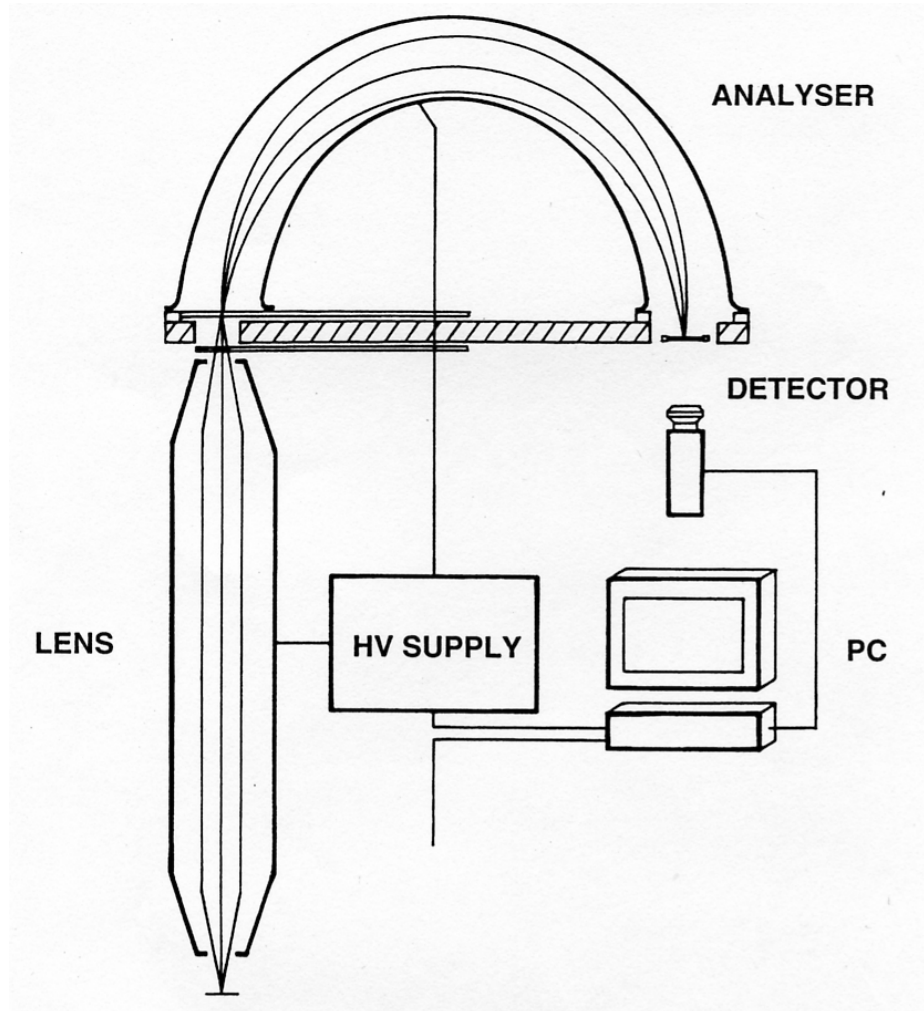


U9
undulator

CGM

Scienta
SES 200
analyzer

Hemispherical electron energy analyzer

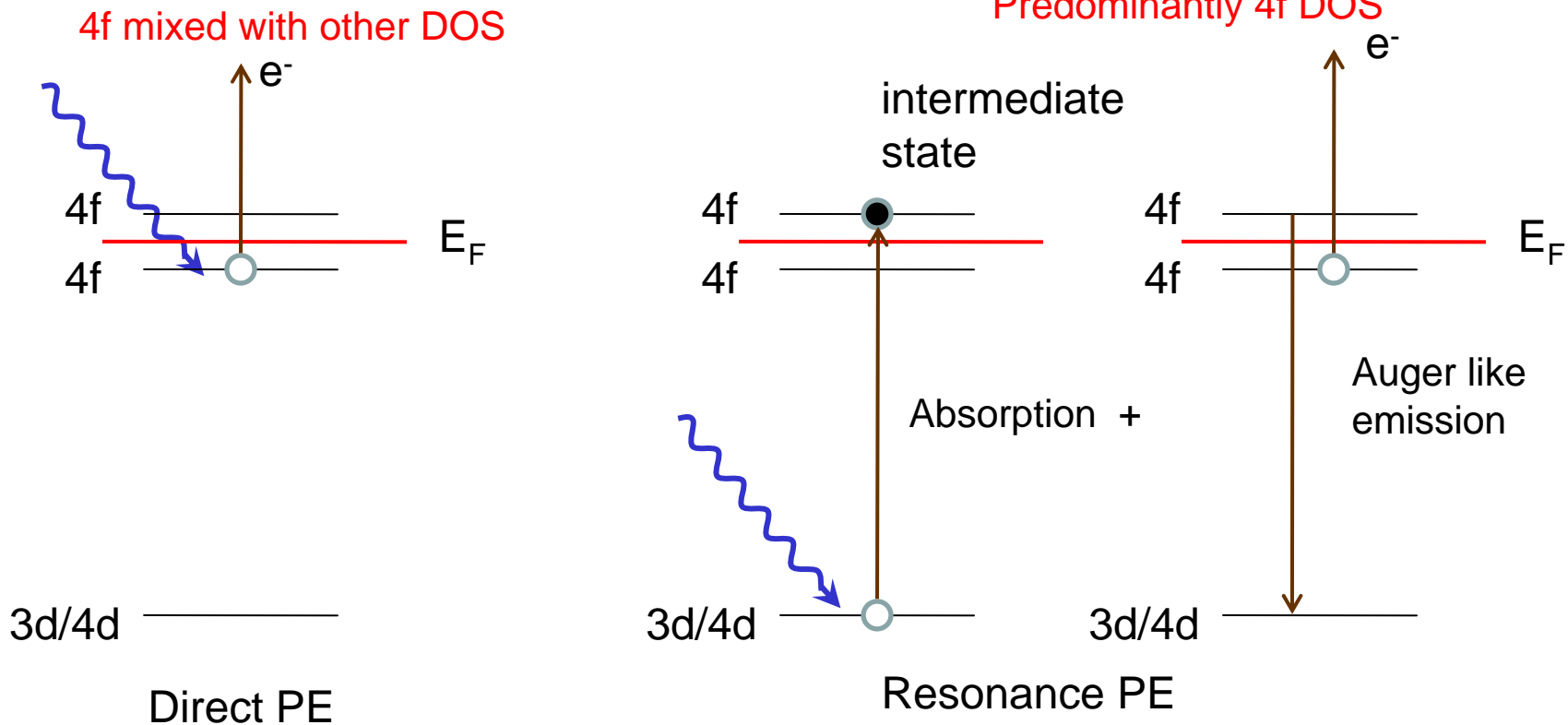


R_1 : radius of inner sphere
 R_2 : radius of outer sphere
 $R_0 = (R_1 + R_2) / 2$: mean radius
and along electron path
 V_1 : inner potential
 V_2 : outer potential
 E_p : pass energy = electron
kinetic energy along mean
radius

Resonance photoemission (near-edge absorption followed by Auger like electron emission)

e.g. $\text{Ce}^{3+} (4f^1)$

Intensity enhanced by absorption
Predominantly 4f DOS



Comments on photoelectron IMFP

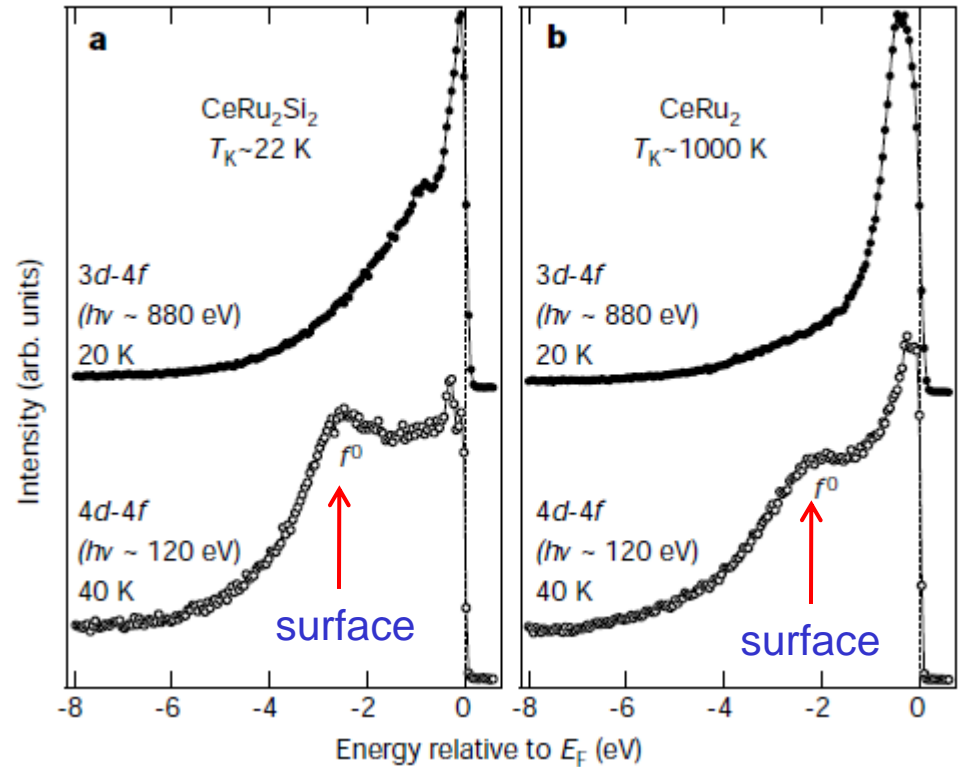
Valence band PE using VUV and SX has IMFP near minimum, very surface sensitive. It is great to probe surface electronic structure such as surface states and surface resonances.

Many strongly correlated systems have electronic structure sensitive to coordination, thus surface contains different electronic structure from that of deeper bulk. Great surface sensitivity posts a serious problem to probe true bulk properties.

Need larger IMFP by using higher energy photons to enhance bulk sensitivity.

Probing bulk states of correlated electron systems by high-resolution resonance photoemission

A. Sekiyama*, T. Iwasaki*, K. Matsuda*, Y. Saitoh†, Y. Ônuki‡ & S. Suga*



By using Ce $3d \rightarrow 4f$ Res. PE near 880 eV surface 4f component becomes greatly reduced compared to $4d \rightarrow 4f$ Res. PE near 120 eV, the resulting spectra are closer to true bulk 4f DOS.

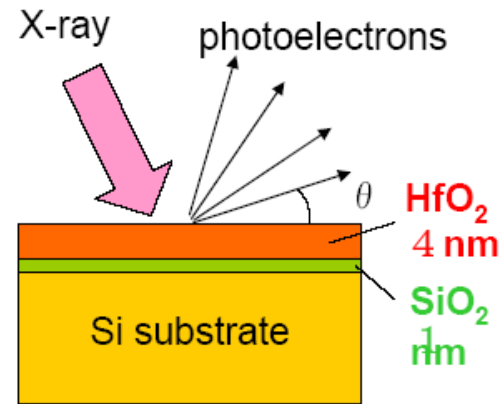
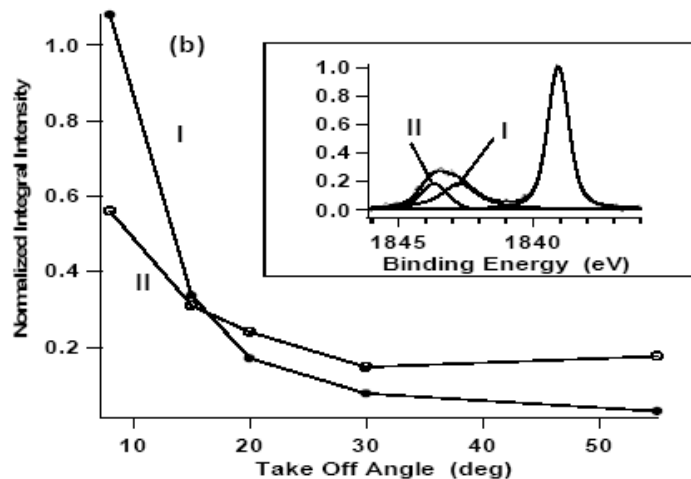
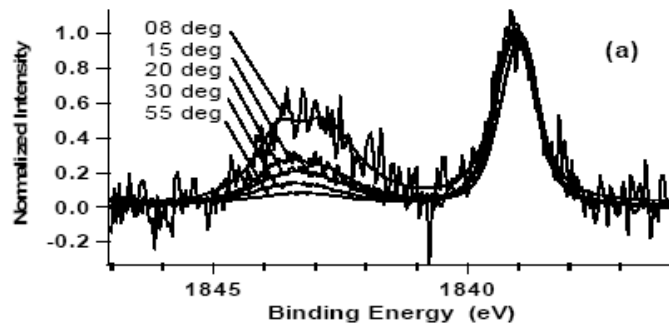
Drive to go to even higher photon energies into hard x-ray regime

HARD X-ray PhotoEmission Spectroscopy (HAXPES)

HAXPES not only reach even closer to **true bulk properties** of strongly correlated systems, but also becomes capable of probing **interface electronic structure**, Very difficult using conventional VUV/SX.

HAXPES example: Hard x-ray photoemission on Si-high k insulator buried interface

Kobayashi, APL 2003 **S**Pring-8



Annealed sample
HfSix formation

$h\nu = 6 \text{ keV}$, $\Delta E \sim 0.24 \text{ eV}$

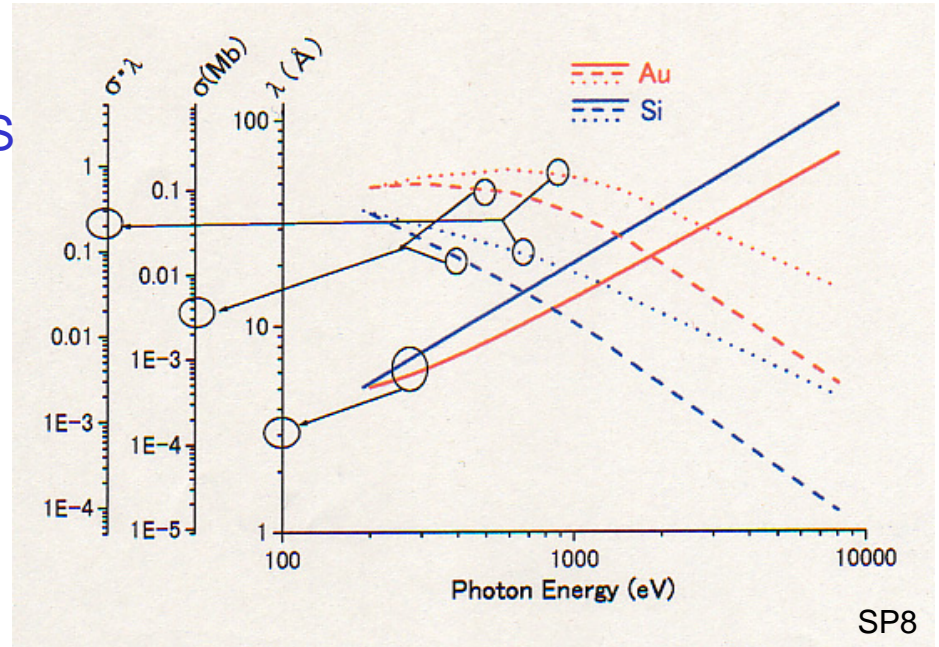
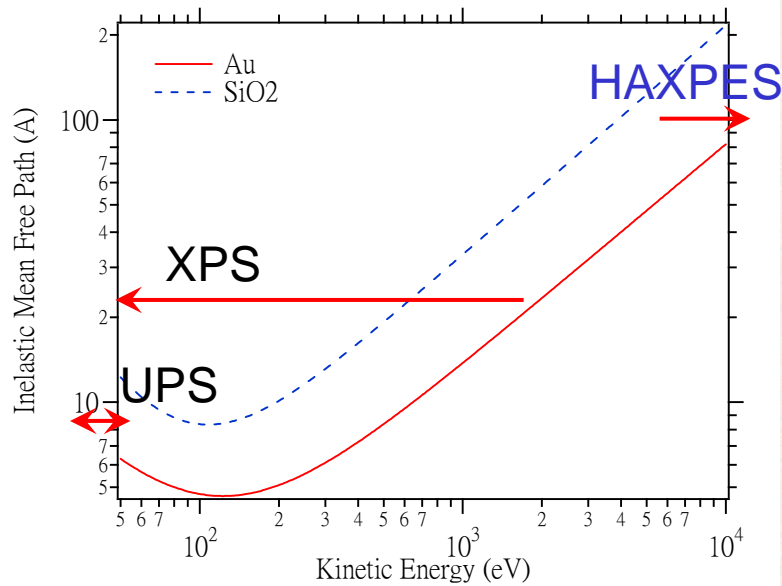
Take-off angle dependence \Rightarrow non-destructive depth profile

Can probe buried interface at 35 nm ! (achievable only by hard x-ray PE)

NSRRC HAXPES project at SPring-8

Why Hard X-rays?

Electron IMFP (probing depth) and Cross section



Higher E_k for deeper probing depth or more bulk sensitivity, for strongly correlated systems and interface properties

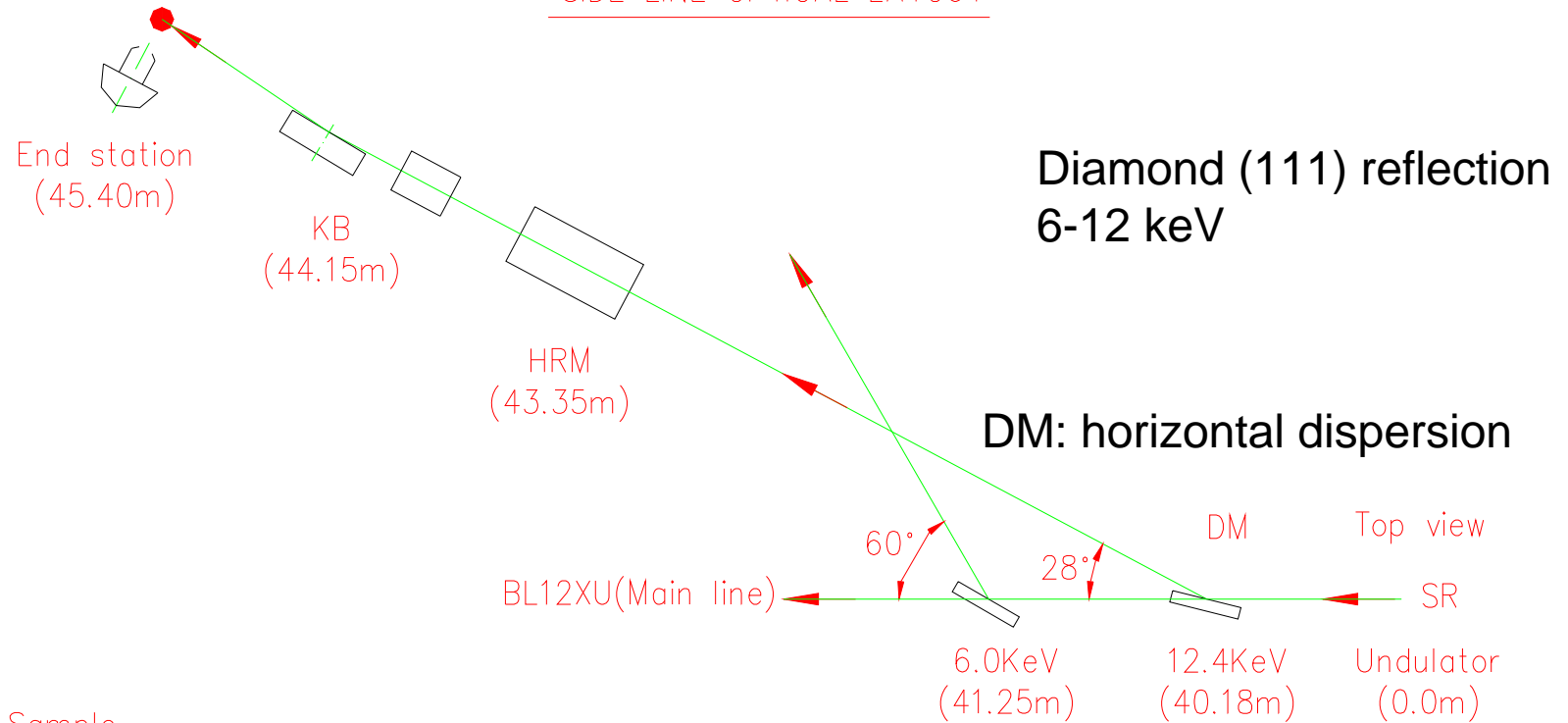
Photoemission signal ($\sigma \cdot \lambda$) decreases rapidly > 1 keV

Need photon source of higher flux/brightness (modern SR), efficient BL design and good electron analyzers

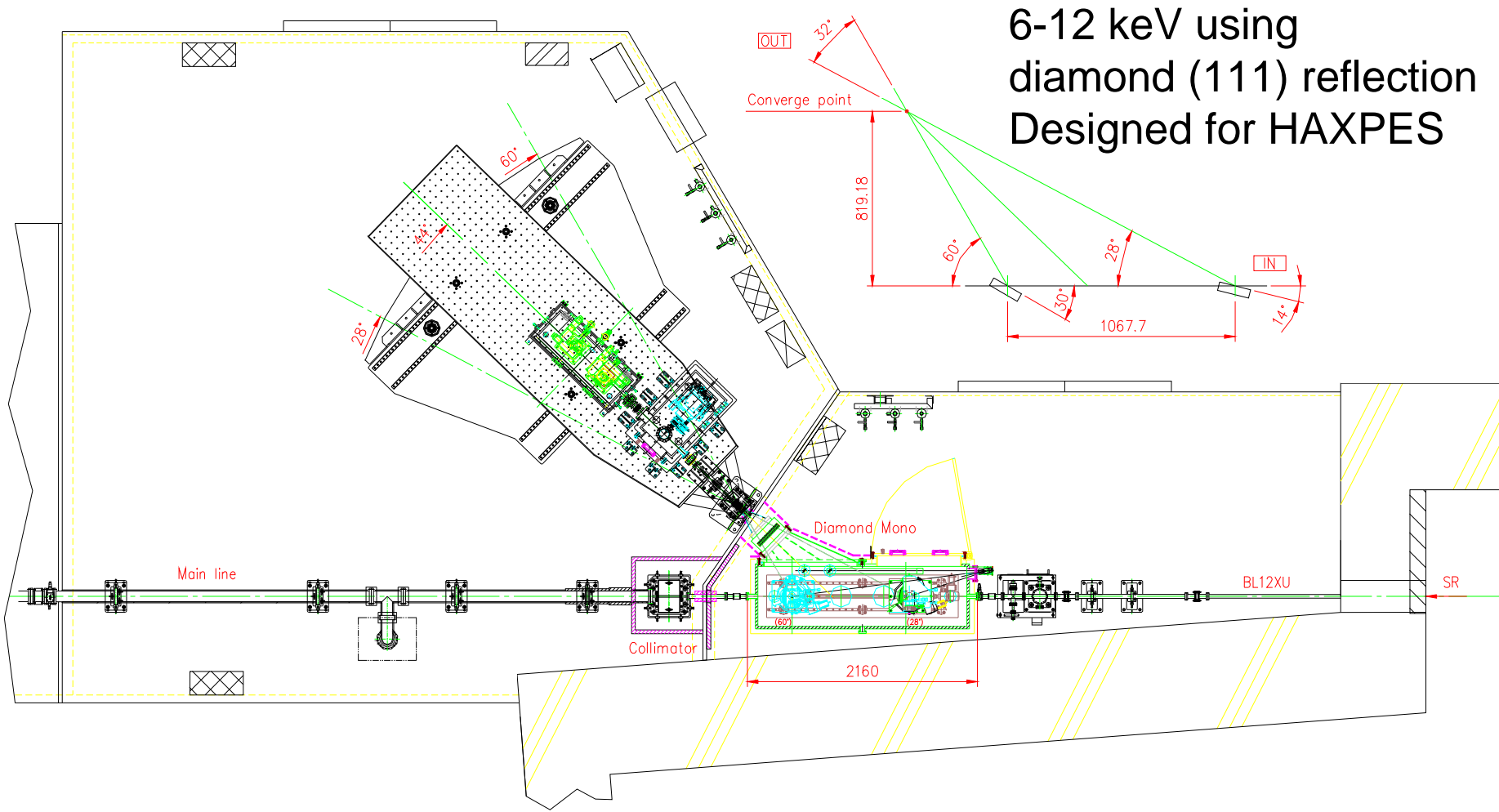
HAXPES is a low count rate, photon hungry experiment!

Optical design concept

SIDE LINE OPTICAL LAYOUT



HRM: vertical dispersion



6-12 keV using
diamond (111) reflection
Designed for HAXPES

Layout of the side beamline of BL12XU

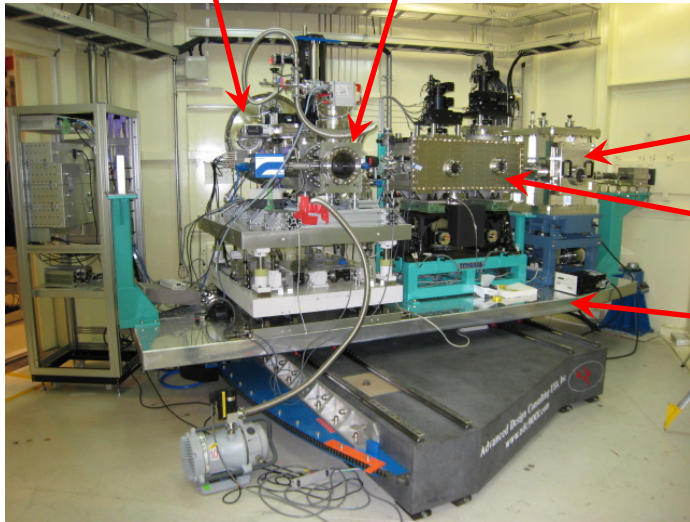


2007/11/15

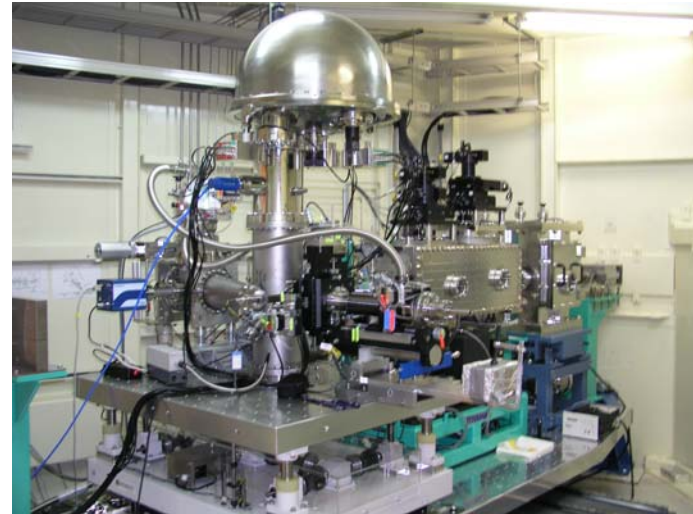
Diamond monochromator: installed Aug. 3, 2007

Commission of SPring-8 BL12XU SL HAXPES end station

MBS energy analyzer End station

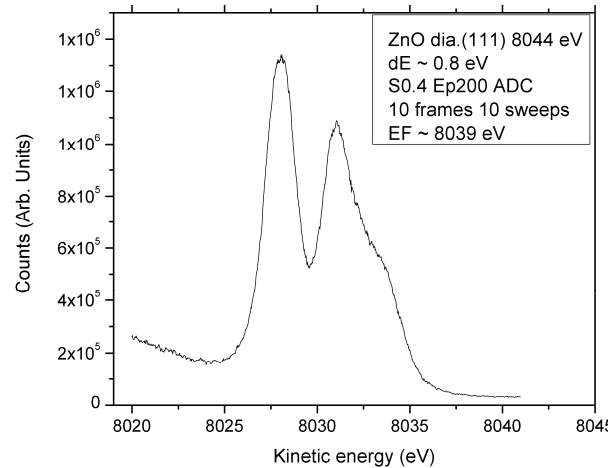


Horizontal setup
High Res. Mono.
KB focus mirrors
Rotational platform

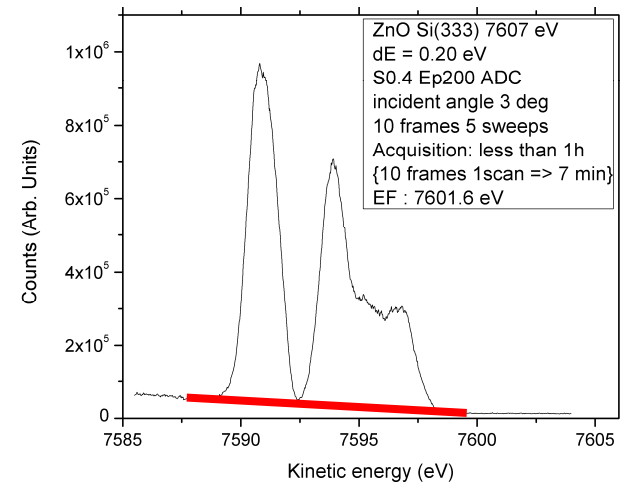


Vertical setup

KB Focus at sample
Aft HRM Si(333)
7.6 keV
38x38 microns



Low resolution w/o HRM
8 keV



Medium resolution
Si(333) HRM, 7.6 keV

In collaboration with
Cologne U of Germany

Challenging future directions of Photoemission Spectroscopy

1. ARPES at submicron to tens of nanometer scale, using Schwatzchild optics or zone plates.
Need brighter light sources.
2. Time-resolved PES.
Pump-probe: dynamics.
Need efficient detection and brighter sources.
lasers or laser+SR.

Thanks for your attention